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N₂-H₂ capacitively coupled radio-frequency discharges at low pressure. Part II. Modelling results: the relevance of plasma-surface interaction.

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Abstract

In this work, we present the results of simulations carried out for N_2 -H₂ capacitively coupled radio-frequency discharges, running at low pressure (0.3–0.9 mbar), low power (5–20 W), and for amounts of H₂ up to 5%. Simulations are performed using a hybrid code that couples a two-dimensional time-dependent fluid module, describing the dynamics of the charged particles in the discharge, to a zero-dimensional kinetic module, that solves the Boltzmann equation and describes the production and destruction of neutral species. The model accounts for the production of several vibrationally and electronic excited states, and contains a detailed surface chemistry that includes recombination processes and the production of NH_x molecules. The results obtained highlight the relevance of the interactions between plasma and surface, given the role of the surface production of ammonia to the neutral and ionic chemistry of the discharge.

Keywords: cold plasma, CCP discharge, N2 H2 mixture, modelling, plasma surface interactions

1. Introduction

Low pressure N_2/H_2 plasmas are of interest in a wide variety of fields, from fusion to planetary science, and even in technological-driven research their study often involves a fundamental component, to deepen the knowledge on these systems.

In fusion research, the focus lies on the use of N_2 to attenuate the local heat loads on tungsten divertors [1]. N_2 acts as an efficient extrinsic radiator, but in turn it creates a series of setbacks to the plasma operation, namely the implantation of nitrogen and nitriding of plasma-facing materials, sputtering caused by energetic nitrogen ions, and the formation of tritiated ammonia which conditions the operation of gas plants and cryopumps, and influences the nature of the walls [2,3]. The study of NH_3 formation and of strategies for its mitigation is one of the current priorities in fusion research [4,5]. If a carbon material is used at the divertor plates, sputtering can lead to the formation of tritiated hydrogenated amorphous carbon in the surfaces [6,7]. Laboratory experiments in conditions similar to those of the divertor region have shown a reduction in the formation of these compounds when introducing N_2 in an H_2/CH_4 plasma mixture [8].

Plasmas containing N_2/H_2 are extensively used in technological applications up to the nanoscale level [9], including deposition of thin films [10-12], etching of organic low permittivity films [13,14], surface treatment by nitriding of metals [15,16] or semiconductors [17,18], carbon nanotube functionalization [19], and catalyst

pretreatment for carbon nanotube growth [20,21]. A better insight into the plasma kinetics and plasma surface interactions is essential for many of these applications.

The study of complex plasmas generated from N₂/CH₄ gaseous mixtures in capacitively coupled radiofrequency (ccrf) discharges is also a very active field of research. A particular application of this type of discharges is in the simulation of the chemistry of Titan's atmosphere, in laboratory environment. In general, these studies use N₂/CH₄ mixtures with low concentrations of methane (< 10%), yet leading to the formation of dust particles analogues to the *tholins*, the solid organic aerosols found in Titan [22]. In Titan's atmosphere, these aerosols are thought to be produced at high altitudes by chemical processes induced by solar radiation and energetic charged particles, both from Saturn's magnetosphere and the solar wind [23]. Since in laboratory plasmas the chemistry is driven by electrons, the characterization of the plasma source and maintenance mechanisms is useful to identify the key processes responsible for particle formation. To this end, a number of different works have been carried out in direct current (dc) discharges [24-28], microwave discharges [32], corona discharges [32,33], dielectric barrier discharges [34] and ccrf discharges [35,36]. In order to gain insight into the effect of the discharge conditions on the plasma reactivity, but without addressing the additional complexity of dust production, plasmas created from mixtures of N₂ with H₂, a product of CH₄ dissociation, may be used instead.

Low pressure N_2/H_2 plasmas have been extensively studied in the last decades, both experimentally [37-49] and theoretically [38,40,47-53]. Most of the experimental effort has focused on the synthesis of ammonia [39,41,42,45,46] and the role of plasma-surface interactions in NH₃ production. Different experiments showed that ammonia generation was dependent on the materials of the electrodes and the walls of the plasma reactor, with stainless steel, iron or platinum displaying a catalytic effect larger than other metals or oxides [37,39,41,42,45,46,54,55]. The prospect of plasma-assisted ammonia synthesis at the industrial scale, with the aim of eventually surpassing the efficiency of the thermochemical Haber-Bosch process, is currently a subject of intensive investigation [54,56,57].

On the theoretical side, the first models of H_2 and N_2 plasmas mainly focused on gas-phase volume reactions and vibrational kinetics [50,51]. Surface processes were included subsequently by Gordiets *et al.* [52,53], in order to explain the formation of ammonia, and in the study of the nitriding of iron substrates in this type of discharges [40]. The interaction of the radicals generated in the plasma with the surface of different materials has been analyzed in various works [47,49,54,58], with the aim of determining the relevance of the different surface processes.

The present two-part work studies ccrf discharges, produced in a mixture of N_2 with small amounts of H_2 (up to 5%), combing both experimental and modelling techniques. This twofold approach is meaningful, considering the complex space-time features of these plasmas, associated with an enhanced volume and surface reactivity. Indeed, by using a model validated against experiment, one can further analyze simulation results to obtain complementary information about the plasma behavior, namely on the rates and paths leading to the production/loss of species. Here, plasmas are produced in a cylindrical parallel-plate reactor surrounded by a grounded metallic cage, corresponding to the PAMPRE experiment [22], with effective coupling powers in the range of 3-13 W and pressures between ~ 0.3 and 1 mbar. In the first part of this study, corresponding to the companion paper [59] hereafter mentioned as I, we presented an experimental characterization of the discharge for the different working conditions, comprising the main electrical parameters, the electron density measured with a resonant cavity technique, and the abundances of stable neutral species and positive ions measured with quadrupole mass spectrometry and infrared (IR) spectroscopy. This paper corresponds to the second part of the study, where simulation results obtained with a hybrid model are presented and compared to the measurements of I. The hybrid model couples a 2D fluid module describing the dynamics of the charged particles with a homogeneous (0D) kinetic module containing a very complete description of the plasma chemistry, both in volume and surface phases. Model validation is based on the measurements of the electrical parameters, the electron density and the fluxes of ions at the wall, as obtained as a function of the effective power coupled to the plasma. Special focus is put on the plasma interaction with the surfaces, highlighting the relevance of secondary electrons in the discharge parameters and the heterogeneous chemistry at the reactor walls, the latter playing a key role in the synthesis of ammonia.

The organization of this paper is the following. Section 2 highlights the most significant model features, to describe both the discharge dynamics and the chemical kinetics. Section 3 presents and discusses the main results obtained, as a function of the effective power coupled to the plasma and at various concentrations of H_2 . In 3.1 we focus on the electric characterization of the discharge, the plasma electron density and the ionization rate, whereas 3.2 is dedicated to the main results on the neutral and ion species, including ammonia formation. Section 3.3 details the main processes responsible for the kinetics of the discharge. Section 4 concludes.

2. Model description

The model employed in this work is based on the ones previously developed by the authors for pure nitrogen [60] and hydrogen [61] ccrf discharges. It is a hybrid code that couples a 2D (r,z) time-dependent fluid module characterizing the dynamics of charged particles with a very complete 0D kinetic module. The latter includes an extensive set of volume and surface reactions, which are detailed in Table A1 of the appendix.

A detailed description of both the fluid and the kinetic modules can be found in [60]. The fluid module solves the continuity and the momentum transfer equations for electrons, positive ions N^+ , N_2^+ , N_3^+ , N_4^+ , H^+ , H_2^+ , H_3^+ , N_2H^+ , NH^+ , NH_2^+ , NH_3^+ and NH_4^+ , and negative ions H^- and NH_2^- , the electron mean energy transport equations, and Poisson's equation for the rf electric potential. The stationary drift-diffusion approximation is adopted for the particle and energy flux equations, with the introduction of an effective field in the specific case of the ions [59]. The local mean energy approximation is used to obtain the electron transport parameters and the rate coefficients from the space-time electron mean energy profile.

In the fluid module, the electron density n_e and mean energy ε are obtained from the following continuity equations and boundary conditions:

$$\frac{\partial n_e}{\partial t} = -\frac{1}{r} \frac{\partial (r\Gamma_{e_r})}{\partial r} - \frac{\partial \Gamma_{e_z}}{\partial z} + S_e \tag{1}$$

$$\frac{\partial(n_e\varepsilon)}{\partial t} = -\frac{1}{r}\frac{\partial(r\Gamma_{\varepsilon_r})}{\partial r} - \frac{\partial\Gamma_{\varepsilon_z}}{\partial z} - \overrightarrow{\Gamma_e} \cdot \vec{E} - S_{\varepsilon}$$
(2)

$$\left. \frac{\partial n_e}{\partial r} \right|_{r=0} = \left. \frac{\partial n_e}{\partial z} \right|_{r=0} = 0 \tag{3}$$

$$\frac{\partial(n_e\varepsilon)}{\partial r}\bigg|_{r=0} = \frac{\partial(n_e\varepsilon)}{\partial z}\bigg|_{r=0} = 0$$
(4)

where *E* is the electric field, $\Gamma_{e/\epsilon}$ is the electron particle/energy flux, *S*_e is the net production rate of electrons, and *S*_{ϵ} is net power density lost by the electrons due to elastic and inelastic collisions.

This set of equations for the plasma (slow) electrons is complemented by a single-beam model for fast electrons generated by secondary emission at the walls, following the one proposed for dc discharges in [62], where a detailed formulation can be found. The model considers a beam of monoenergetic fast electrons travelling in a straight line perpendicular to the emitting surface, and solves the evolution of the beam flux and energy along its path. The fast electrons are assumed to be created at the surfaces in contact with the plasma (both electrodes and the surrounding cage) by impingent positive ions, and their initial energy is set to 1 eV (numerical tests showed that simulation results are not sensitive to variations of this value within 50%). At the surface, the fluxes *j* of fast electrons (signaled with subscript *f*) and positive ions (+) are related by:

$$j_f = -\gamma j_+ \tag{5}$$

where γ is the secondary electron yield. This parameter is adjusted to fit the experimental trends of the electron density as a function of the effective power coupled. The coupling between fast and slow electrons is as follows. As fast electrons traverse the sheath, they are accelerated by the electric field. When their energy is larger than the ionization threshold, they can be responsible for the ionization of neutrals and the production of new beam electrons, thus increasing its flux and reducing its energy. The beam is fully diluted into the plasma when the fast electrons reach the negative glow. There, ionizations produce slow electrons instead, and the beam energy is progressively lost to inelastic collisions (both ionizations and excitations) until it lies below the lowest excitation threshold, in which case the beam electrons become part of the (slow) plasma electrons. The particle and energy balance equations for the beam (fast) electrons are written as in [63]:

$$\frac{\partial n_f}{\partial t} = -\nabla_{\perp} \left(n_f u_{\perp f} \right) + S_f \tag{6}$$

$$\frac{\partial(n_f \varepsilon_f)}{\partial t} = -\nabla_{\perp} \left(n_f u_{\perp f} \varepsilon_f \right) + n_f u_{\perp f} E_{\perp} - S_f^{\varepsilon}$$
(7)

where u_f is the drift velocity, S_f and S_f^{ℓ} are the source and loss terms for the particle and energy balance equations, respectively, and \perp represents the vector-components perpendicular to the walls. Equations (6)-(7) are solved by numerical integration over a discrete grid that enhances the spatial description of the space-charge sheath (typical cell-sizes of 0.5 mm). Its solution coupled to the plasma equations (1)-(2) is particularly relevant to self-consistently account for changes in the electric field and the plasma source terms, leading to calculated values of the electron density much closer to the measurements at high powers.

The 0D kinetic module solves the two-term homogeneous and stationary electron Boltzmann equation for the main plasma species N_2 , H_2 , NH_3 , N, H (accounting for inelastic collisions from ground-state molecules and atoms, and inelastic and superelastic collisions involving vibrationally excited states), and the set of (average) rate balance equations for 78 additional neutral species. These include the 15 vibrational states of $H_2(X)$ and the 46 of $N_2(X)$, 8 electronic excited states (7 for N_2 and 2 for N), 5 adsorbed species (N(s), H(s), NH(s), $NH_2(s)$ and the free surface sites F), and other molecules and radicals. The steady-state solution of the 0D rate balance equations is computed after every few rf cycles solved by the fluid module, but contrary to [60], this is done by means of a stiff solver (LSODE [64]) that calculates the time evolution of the system to ensure the stability of the solution, instead of directly solving the stationary form of the species balance equations.

For the kinetic scheme, we have combined the reactions from our previous models for N₂ [60] and H₂ [61], complemented by additional processes involving both species, taken mostly from [52] and [65]. The rates for electron-impact processes are calculated using up-to-date cross section sets from the IST-Lisbon [66,67] (N₂ [68-70], N [71,72], H₂ and H [61,73-82]) and Hayashi (NH₃) [83,84] databases, available at LXCat. The vibrational processes involving both N₂ and H₂ are taken from [52]. In the case of the e-V processes in N₂, the IST-Lisbon database contains only the cross sections for the excitation from the ground-state to the first 10 vibrational levels. The rate coefficients for $v \ge 1$ are calculated from the former using the same scaling law as in [71]:

$$k_{v,v+n}(T_e) = \frac{k_{0,n}(T_e)}{1+av}, \quad 1 \le n \le 10 \quad ; \quad 0 \le v \le 45$$
(8)

and taking a = 0.15.

The surface chemistry model, describing the multi-step formation of ammonia at the reactor walls, is mainly taken from [47]. The reaction set has been extended to include the dissociative adsorption of molecules following [58]. The coefficients given in [47] correspond to a stainless steel surface, while the PAMPRE experiment features a mixing of stainless steel (electrodes) and aluminium alloy (cage) walls. As noted in [58], the reaction coefficients can vary significantly depending on the surface material, and in particular, a reduction of an order of magnitude is expected for Al_2O_3 , which could be present in our experiment. Thus, the set of

reaction coefficients has been tweaked towards lower reactivity to account for this and better fit the experimental NH_3 abundances.

The rates due to the flow of species in and out of the chamber are calculated similarly to [85]. The rate at which precursors enter the chamber is given by:

$$R_{in} = 4.49 \times 10^{17} Q_{in} / V \,\mathrm{cm}^{-3} \,\mathrm{s}^{-1} \tag{9}$$

where Q_{in} is the inlet flow in sccm and V is the reactor volume in cm⁻³. To balance the possible changes in the number of particles in the reactor due to the plasma kinetics, the rate at which a species X leaves the reactor is calculated as:

$$R_{X,out} = R_{in} \frac{n_X}{n_{T,0}} \tag{10}$$

where n_X is the density of species X and $n_{T,0}$ is the total particle density in the chamber before discharge ignition. This ensures the conservation of pressure throughout the simulation.

The solution of the model is obtained by alternate iterations of the fluid and the kinetic modules. Typically, 200 rf cycles are solved with the fluid module, between calls to the kinetic module. The solution to the fluid module gives the effective power coupled to the plasma (W_{eff}) and the self-bias voltage (V_{dc}), along with the space-time evolution of the charged-particle densities, fluxes and electron-impact reaction rates; the electron mean-energy and energy-flux; and the space-charge electric field. From these results one can calculate the space-time averaged reaction rates involving charged species, which are used in the kinetic equations of the 0D module to obtain the volume and time-averaged densities and reaction rates for the neutral species. These newly calculated densities are used as input to solve the electron Boltzmann equation, and the resulting updated electron transport parameters and rate coefficients are then employed in the following iteration of the fluid module.

To reduce the convergence time of the code, a preliminary solution is quickly obtained by using a large timestep. This leads to a somewhat inaccurate treatment of the transport, but nevertheless constitutes a very good starting point for the final solution, which is then reached by reducing the timestep to an adequate value. Overall, runtimes can be reduced by up to 70% by using this method (for convergence criteria imposing relative errors for the calculated quantities below 10⁻³, typical runtimes of 24–100 hrs are obtained in an Intel-Xeon E2697 V2 (2.7 GHz) CPU).

3. Results and discussion

This section presents and discusses the main results obtained in the simulations, comparing them with the measurements available (see I). Similarly to the experiments, the working conditions are for pressures in the range of 0.36-0.92 mbar (gas flows between 20–55 sccm) and coupled powers in the range of 1-15 W, considering N_2 -H₂ mixtures with H₂ fractions up to 0.05.

Note that the model uses as input parameter the rf-voltage $V_{\rm rf}$ applied to the driven electrode, yielding $W_{\rm eff}$ as self-consistent result [59,60]. However, we have preferred to use the latter in the comparisons with the experiment, as in [59], considering that $V_{\rm rf}$ was not measured at the electrode [59] and that $W_{\rm eff}$ provides direct information about the power available for plasma excitation.

3.1 Electrical parameters and electron density

The results for the electrical parameters of the discharge are shown in Figure 1. Here, calculated and measured values of the electron density and the self-bias voltage are displayed as a function of the coupled power, for a mixture with 0.05 H_2 fraction at two different pressures (0.50 and 0.92 mbar).



Figure 1. Simulations (curves) and measurements (points) for the electron density (upper panel) and the self-bias voltage (lower panel), as a function of the power coupled to the plasma, for a mixture with 5% H_2 at the following pressures (in mbar): 0.5 (blue circles and lines); 0.92 (red squares and lines). The dotted curve was obtained at 0.92 mbar, neglecting the electron production by secondary emission.

Both the experiments and the simulations show that the electron density increases linearly at low power values, exhibiting an exponential growth at higher powers. An increase in the pressure (hence in the gas density) leads to a displacement of the curve $n_e(W_{eff})$ towards higher effective powers as expected, without changing its global behavior. In general, model predictions underestimate the electron density, and this is more evident at the lower pressure where a factor of two difference can be found with respect to the experimental values. At high power, the exponential growth is entirely due to the secondary electron emission. If the contribution from the secondary electrons is not included, the electron density exhibits a purely linear growth with the power, as shown in fig.1. As mentioned, the secondary electron yield γ is adjusted to fit the highest n_e value for each pressure, resulting in $\gamma = 0.09$ at 0.50 mbar and $\gamma = 0.06$ at 0.92 mbar. These values are in the typical range for this type of discharges [86,87], and the decrease in the yield with increasing pressure can be justified by the lower energy of the heavy particles reaching the walls [87].

As expected, the self-bias voltage increases with the coupled power and decreases with the pressure, in direct relation with the intensity of the ion current density at the reactor walls. Model predictions for V_{dc} are in good qualitative agreement with the measurements, reproducing the behavior of this parameter with changes in both W_{eff} and p. The calculated values underestimate the measurements at low power, but this difference is reduced as the coupled power increases. The model behavior is mostly linear, somewhat deviating from that trend when the secondary electron emission becomes significant.

In the experimental part (see I), a weak upwards trend was observed for the electron density when increasing the hydrogen content in the precursor mixture at constant power. The corresponding model results are shown in Figure 2.



Figure 2. Electron density as a function of the power coupled to the plasma, at a pressure of 0.92 mbar and for different H_2 fractions in the gas mixture (in percentage): 0 (black), 1 (red), 3 (blue), 5 (green). Upper panel: simulations. Lower panel: experiments.

Here we observe a behavior different from the experiments. The lowest electron density is also obtained for the pure N₂ discharge, however, instead of a smooth increase with the H₂ fraction, a sharp jump in n_e is found for the 1% H₂ mixture. Moreover, further addition of hydrogen results in a steady decrease of the electron density, although the value at 5% is still above the pure N₂ result. This discrepancy might be due to several factors. First, because of the exponential growth behavior of n_e at high powers, a small error in the determination of W_{eff} , either in the experiments or in the model, could be enough to change the observed behavior. Second, this trend is specifically observed at higher powers, where ionization is dominated by the secondary electron production (see the discussion below). Since the model for fast electrons is rather simplified, fine variations such as this one should be taken with caution.

Typical electron energy distribution functions (EEDF, $f(u)\sqrt{u}$, normalized so that $\int_0^{\infty} f(u)\sqrt{u}du = 1$) obtained for the slow electrons are shown in Figure 3, for pure N₂ and 5% H₂ mixtures, at p = 0.92 mbar, $W_{\text{eff}} = 5$ W and 11.5 W, and for two different positions along the discharge axis, corresponding to the plasma bulk (half-way between the electrodes) and within the space-charge sheath. Under low power conditions, slow electrons are responsible for most of the ionization processes and fast electrons are less relevant. In this case, an observable difference is found between the distributions in the bulk and in the sheath, the latter showing a significantly populated tail up to 12 eV, while the former drop more abruptly. Further examination of the results

reveals that, starting at energies > 3 eV (beyond the peak of the distribution), the EEDFs in the sheath are $\sim 10-100$ times larger than in the bulk, yielding significant differences in the efficiency of electron-impact excitations and ionization in both regions.



Figure 3. Calculated EEDFs of the plasma (slow) electrons, at 0.92 mbar and for two different positions along the discharge axis, corresponding to the plasma bulk (solid lines) and within the space-charge sheath (dashed). The upper panel is for a low-power of 5 W, in pure N₂ (black curves) and 5% H₂ mixtures (red); the lower panel is for a high-power of 11.5 W, in pure N₂ (black curves) and 0.1% H₂ mixtures (red).

Much smaller differences are found when comparing the EEDFs for different gas compositions, at low power. In this case, and for both bulk and sheath regions, the addition of H_2 to the mixture results in only a slight increase of the EEDF tail, with the corresponding decrease of its body, thus leading to minor changes in the electron-impact excitation and ionization rates (in agreement with the results in Figure 2). Under high power conditions, the EEDFs for slow electrons are very similar in different regions and at different gas compositions. A small increase in the body of the distributions is observed in the bulk region or for 0.1% H₂ mixtures, translating into a ~10% decrease in the ionization rate, contrary to what one could expect from Figure 2. Indeed, the results therein revealed a non-monotonic variation of the electron density with the percentage of H₂ in the mixture, probably associated with the production of fast secondary electrons, which would control electron-impact ionization phenomena.

The influence of the fast electrons in the plasma can be visualized by comparing the time-averaged densities, mean energies and ionization rates for both slow/fast electrons. The results are shown in the contour plots of Figures 4 and 5, obtained for a pressure of 0.92 mbar, a high-power of 11.5 W, and H₂ percentages of 5% (Fig. 4) and 0% / 0.1% (Fig. 5). The figures for fast electrons display the added contributions of three beams, originated at the powered electrode, the grounded electrodes and the surrounding cage.



Figure 4. Calculated contour plots of time-averaged densities, mean energies and N_2 ionization rate contributions for slow (left) and fast (right) electrons, for a 5% H₂ mixture at 0.92 mbar and 11.5 W. The spatial scales are normalized to the discharge radius *R* and the interelectrode distance *d*. Note the different color scales in the slow and fast electron plots.

The density and energy panels in Figure 4 highlight the differences between both groups of electrons. The results for the density show that both, fast and slow electrons, are present in the discharge bulk, with slow electrons exhibiting a maximum density closer to the powered electrode (z/d = 1) and fast electrons distributed rather homogeneously at density values ~4 orders of magnitude lower. Indeed, for most of the working conditions considered, the fraction of fast electrons is ~0.01–0.02 % of the total electron density. The results for the energy of fast/slow electrons are essentially the opposite of what is observed for their densities. While slow electrons typically reach mean energies of only ~10 eV due to collisional heating, the fast electron beam can be accelerated up to ~60–80 eV by the electric field, within the sheath close to the powered electrode, and easily sustain 20–40 eV elsewhere, well above the ionization threshold.

The effect of both densities and energies is compounded in the ionization rate. For the comparison, we have chosen to show in the lower panels of Figure 4 the contribution of both groups of electrons to the N_2 ionization rate. As expected, the main ionization region is found in the sheaths, for both groups of electrons and with

similar intensities, but a difference of a few orders of magnitude is encountered in the discharge bulk. While for the slow electrons the ionization in the center of the plasma is negligible, for the fast electrons it becomes a relevant source of charged particles. The result is a significant increase in the volume-averaged electron density, as shown previously in Figures 1-2, and a substantial change in the plasma ion chemistry.



Figure 5. As in Figure 4, but only for fast electrons in mixtures with 0% H₂ (left) and 0.1% H₂ (right).

The variations in the contribution of fast electrons to ionization, at high-power and various mixture compositions, can be analysed in Figure 5. Here, we observe that the slight introduction of H₂ yields a mild increase in the mean energy and a large increase in the electron density and ionization rate, the latter becoming ~20% higher, in agreement with the electron density jump observed in Figure 2 when the mixture composition goes from 0% to 0.1% H₂. The major cause for this effect is related with the reduction in the ionization threshold for hydrogenated gas mixtures, which is then set at 10.2 eV (corresponding to NH₃) instead of the 15.4 eV (for N₂) required to ionize pure nitrogen discharges. This ionization uprise is probably overestimated by the model adopted for the fast electrons beam, where the ionization threshold controls the beam-growth in the sheath and its decline in the bulk. The effect is naturally mitigated with the continuous increase in the H₂ content (due to the enhanced contribution for the ionization of both N₂ and H₂, with similar thresholds), as it is also observed in Figure 2.

3.2 Ion and neutral densities and fluxes

The behavior of charged particles can also be analyzed through the ion fluxes or density profiles. Figure 6 compares the major ion fluxes perpendicular to the walls, measured with a quadrupole mass spectrometer (QMS) (see paper I) and predicted by the model within a rf cycle (average value) along the *z* axis at r = R. The results reveal that the most abundant ion is N₂H⁺, whereas the fluxes for N₂⁺ and NH₄⁺ are found to be significantly lower. Simulations show a similar behavior for all positions along the *z* axis, but the values of the fluxes are closer to the measured ones in the sheath region where the electron mean energy and the ionization rate are higher (note that the QMS measurements are performed approximately halfway between electrodes). This result, together with the lower electron densities predicted at low powers, confirms that the model predictions underestimated the ionization rate in the bulk.



Figure 6. Normalized ion fluxes to the wall at r=R, as a function of the normalized distance to the grounded electrode, for N₂⁺ (black lines), N₂H⁺ (red) and NH₄⁺ (blue), for a 5% H₂ mixture at two different pressures: 0.92 mbar, 10 W (upper panel) and 0.5 mbar, 6 W (lower panel). The solid lines are model simulations and the dashed lines and shades represent the value measured with the QMS, at approximately z=d/2, and its error.

Figure 7 shows the measured and simulated ion fluxes at the wall as a function of the H₂ fraction in the mixture. Overall, the behavior of the ions is well reproduced, specifically the NH₄⁺ and N₂H⁺ growth and N₂⁺ decrease as hydrogen is injected. The normalized fluxes of the four major ions in the discharge (N₂H⁺, NH₄⁺, N₂⁺, and NH₃⁺) are very well reproduced, however, certain other somewhat minor species show significant quantitative discrepancies. This is the case for NH⁺, NH₂⁺ and N₄⁺. This discrepancy holds for the rest of the comparisons shown below. Due to this, we have decided to only show the results for the major ions henceforth. A small difference is also observed in the NH₃⁺ trend in what is otherwise a good quantitative agreement between model and experiment. The model overestimation of this ion could possibly be related to the overestimation of the NH₃ abundance for mixtures with < 5% H₂, as will be shown below (see Figure 10). The experimental detection of the pure hydrogenic ions H₂⁺ and H₃⁺ requires a different set of QMS acquisition parameters and cannot be directly related to the rest of the ions (see paper I). They are nevertheless included in the figure to show the trend against the H₂ fraction, but the experimental values displayed there do not represent their normalized ion flux and therefore should not be compared with the model results.



Figure 7. Calculated normalized ion fluxes to the wall as a function of the H_2 content in the mixture for a discharge at 0.92 mbar and 10 W (lines), and comparison with the experimental measurements (dots). Upper panel: major ions. Lower panel: minor ions. Open symbols for H_2^+ and H_3^+ correspond to uncalibrated measurements and do not represent the ion flux (see text).

The evolution of the major ion fluxes with the pressure is depicted in the upper panel of Figure 8. Smaller changes to the distribution are observed in this case, both in the model and in the experiments. However, the trends predicted by the model are smoother than the ones observed experimentally, which is evident in the case of N_2^+ and NH_4^+ . Nevertheless, the global trends are adequately reproduced and the evolution of the rest of the major ions is satisfactorily captured.



Figure 8. Model (lines) and experimental (dots) normalized ion fluxes as a function of the pressure (upper panel) and the power coupled to the discharge (lower panel). Discharge conditions are fixed at 5% H_2 , and 10 W and 0.92 mbar respectively. Only major ions are shown for brevity.

Lastly, the evolution of the major ions with the coupled power is shown in the lower panel of Figure 8. In this case, the comparison between model and experiment is worse than in the previous ones. The model and the experiment show small changes in the distribution, but the trends for these are opposite in most of the cases. The only ions for which the model shows a similar trend to the experiments are N_2^+ and N_2H^+ , and only in the

case of N_2H^+ do we also have a quantitative agreement on the flux. This may be due to the heavy growth in the total ion density associated with an increase in power, which could make the comparison of normalized ion fluxes a bit less accurate than in previous cases. On a related note, higher power values also involve a heavy influence of the secondary electrons in the results, which, as mentioned before, is somewhat simple and perhaps unable to correctly account for the ion chemistry in the discharge.

The flux of ions to the wall does not give a complete idea of the plasma ion composition. Figure 9 (upper panel) presents a comparison between the ion fluxes and the volume-averaged ion densities predicted by the model in the same conditions as the upper panel of Figure 6. The results in this figure show that while the largest ion flux corresponds to the N_2H^+ ion, the volume-averaged densities are dominated by NH_{4^+} , followed by N_2H^+ , with N_2^+ appearing in concentrations up to an order of magnitude lower than the former. Negative ions H^- and NH_2^- , which are trapped in the discharge by the plasma potential and thus have no flux to the walls, are shown to also be present in significant amounts (~1% of the total charge) in the plasma bulk.

The cause of the differences between the volume-averaged densities and the fluxes to the wall becomes clear after analyzing the axial distribution of the three major ions, depicted in the lower panel of Figure 9. N_2^+ is found to be present in significant amounts only in the plasma sheaths, while its concentration drops in the bulk. This behavior is mirrored by N_2H^+ , albeit with higher concentrations at all positions and, particularly, close to the electrodes. Finally, NH_4^+ shows the opposite trend, being mostly absent in the plasma sheaths and quickly growing in the bulk, becoming the dominant ion in this region. Note that the difference in the results for the ion average-densities and wall-fluxes justifies a careful comparison between model predictions and mass-spectrometry measurements, since the latter provide direct information only on the *local* wall-fluxes (see I).

This differences in the ion composition close to the reactor walls and in the discharge bulk can be justified by recalling that the space-charge sheaths are the regions with the higher ionization rates, and especially the one near the rf-driven electrode (see lower panel in Figure 4), due to the strong variation of the electric field in these regions and the presence of energetic secondary-electrons coming from the surfaces. In particular, ionization of N₂ triggers a chain of ion-molecule reactions leading to the formation of NH₄⁺ (see section 3.3):

$e + N_2 \rightarrow N_2^+ + 2e$	(e28)
$N_2{}^+ + H_2 \longrightarrow N_2 H^+ + H$	(im6)
$N_2H^+ + NH_3 \longrightarrow NH_4^+ + N_2$	(im24)



Figure 9. Calculated ion densities and fluxes for the same conditions as the upper panel of Figure 6. Upper panel: normalized ion fluxes at the wall (black bars) and volume-averaged normalized ion densities (red bars). Lower panel:

absolute densities for the three most abundant ionic species, at the axis of the discharge (r = 0) as a function of the distance to the grounded electrode (same color codes as in Figure 6).

and because both ion-molecule reactions are very efficient, the relative abundance of these three ions is controlled by the efficiency of the ionization reaction (e28). In high ionization regions, the equilibrium is displaced towards the formation of N_2^+ , resulting in N_2H^+ being the major ion reaching the surface, while in the center of the discharge, where little ionization takes place, most of these ions are converted into NH_4^+ , if NH_3 is present in sufficient amounts.

The abundance of ammonia plays a key role in the ion plasma chemistry, and is primarily dependent on the balance between electron impact dissociation of the precursors and the subsequent surface recombination. A study of the influence of the discharge working conditions on the formation of NH_3 is shown in Figure 10. The abundance of ammonia is found to increase with the fraction of H_2 , as expected, and with increasing power, yet decreasing when the pressure increases. These trends are qualitatively reproduced by the model, but simulations and measurements disagree in the details of the variation of NH_3 concentration with pressure and power. This is especially evident at low pressure, where model predictions underestimate the NH_3 concentration by a factor of ~ 2 .



Figure 10. Simulations (curves) and measurements (points) of the NH_3 fraction, as a function of the H_2 fraction in the mixture (upper panel), pressure (middle) and power coupled (lower). The standard working conditions are 360 V voltage, 0.92 mbar pressure and 0.05 H_2 fraction; the results were obtained by fixing two of these parameters and varying the other.

As mentioned in section 2, the overall low abundances of NH_3 predicted by the model are the result of adopting a set of wall loss probabilities for low-reactivity surfaces, in reactions w7 - w18 (see Table A1; here, the most relevant parameters, for the sensitivity of model results, are those of reactions w9, w16 and w17). A comparison of model results using different sets of surface parameters can be found in Figure 11. Using the high-reactivity parameters of stainless steel [47] results in ammonia concentrations that are a factor of 3-4 times larger than the ones obtained for the current set of surface parameters, and thus much larger than the ones observed experimentally. Ammonia formation is indeed found to be relatively scarce in the discharge, and a possible explanation is the aluminium-alloy surface of the cage, leading to a much less efficient formation of NH₃ through the multi-step surface process.



Figure 11. Simulations (curves) and measurements (points) of the NH_3 fraction, as a function of the power coupled, for the same conditions as in Figure 10. Simulations used the wall loss probabilities provided in Table A1 (red line) or the values for a stainless-steel surface proposed in [47] (blue line).

The main pathways for ammonia formation are shown in Figure 12, for the same discharge conditions as in the previous figure. It is apparent that the main formation mechanisms of NH_3 do not change in the range of conditions studied. These correspond to the final step of several Langmuir-Hinshelwood reactions (reaction w17 in Table A1), which accounts for about 80% of NH_3 formation at the wall, and the neutralization of the NH_4^+ ion at the reactor walls (w36). This conclusion is in agreement with other works studying the synthesis of NH_3 in $N_2 + H_2$ plasmas [49,54]. Other processes, with minor influence in the formation of NH_3 , do change in relevance, especially when increasing the H_2 fraction in the mixture (in this case the rate of Eley-Rideal reaction (w15) grows by two orders of magnitude), or the discharge power (in which case the ion neutralization by electron capture becoming as relevant as its recombination at the surfaces).



Figure 12. Normalized reaction rates for the main sources of ammonia, calculated for the same conditions as in Figure 10.

Surface coverage is thus the most important factor in the formation of NH₃, and is particularly sensitive to changes in the mixture composition. Figure 13 depicts the fraction of adsorbed species as a function of the H₂ fraction in the discharge. Notably, hydrogen is the most abundant adsorbed species, with only a remainder ~0.5% abundance in the gas phase. This is mainly due to the higher recombination coefficient of N at the surfaces (reaction w8, leading to the formation of N₂) compared to the one for H₂ (w7). For pure N₂ mixtures, where no formation of ammonia takes place, this efficient recombination of N₂ leads to a large amount of free surface sites (~20%). Note that the high H(s) abundance for mixtures with > 1% H₂ hinders the production of NH₃, as a higher N(s) abundance would make NH₃ formation more efficient [49]. Once NH(s) is formed at the surface, the subsequent reactions progress quickly, as evidenced by the low concentrations of both NH(s) and NH₂(s).



Figure 13. Calculated surface coverage fractions, as a function of the H_2 fraction in the mixture, for the same conditions as in Figure 10.

The densities of all neutral species in the model, displayed as a function of the H_2 fraction in the gas mixture, are plotted in the upper panel of Figure 14. The major neutrals in the plasma can be quickly identified in this figure, namely the precursor N_2 and H_2 , the corresponding atoms, and NH_3 . The hydrogen-containing species in this group readily grow when H_2 is added to the mixture, while N_2 and N remain mostly unchanged. The rest of the neutral species, all of the form N_xH_y , are found in very similar quantities about five orders of magnitude lower than that of N_2 , and, in spite of their hydrogen content, are mostly unaffected by the increase in H_2 fraction.



Figure 14. Relative densities obtained from the model as a function of the H_2 fraction for a discharge at 0.92 mbar and 10 W. Upper panel: neutral species. Lower panel: electronic states of molecular and atomic nitrogen.

The lower panel of Figure 14 shows the different electronic states considered in the model for N_2 and N. In the case of N_2 , the ground state clearly dominates the distribution, with the density of the largest excited state, $N_2(A)$, amounting to ~0.01% of that of $N_2(X)$. Most of the densities of the excited states show a slight decrease as the H_2 fraction is increased. A somewhat similar situation is found for N atoms, although in this case the densities of the metastable states N(P) and N(D) are closer to the ground state (~1% of N(S)). The addition of H_2 also results in a very small increase of the N(S) density, while both excited states are found to decrease in a similar way to those of N_2 .

Increasing the H_2 fraction in the mixture also leads to significant differences in the vibrational distribution functions (VDF) of $N_2(X)$ and $H_2(X)$. This is shown in Figure 15. The VDF for $N_2(X)$ in pure N_2 plasmas shows

a large plateau for states with v > 10, starting to decrease again only for the largest values of v included in the model (v > 40). As soon as a small amount of H₂ is added, the length of this plateau is strongly reduced, with the second drop shifting to v > 20. The shape of the N₂(X) VDF does not change significantly for mixtures with more than 1% H₂.



Figure 15. Calculated vibrational distribution functions for N_2 (upper panel) and H_2 (lower panel) molecules in the electronic ground-state, for various H_2 fractions in the mixture and the same conditions as in Figure 10.

In the case of H₂, the largest difference is also observed in the 0.1% - 1% H₂ fraction range. In this case, the H₂(X) VDFs are virtually identical up to v = 9, for all mixtures. After this point, a population inversion is observed which is more significant when H₂ is less abundant in the mixture. This population inversion did not occur in the work of Gordiets et al. [52], although a small plateau for *v*-values between 9 and 12 was observed.



Figure 16. Rate coefficient for reaction v6, $N_2(X,v) + H_2(X,w) \rightarrow N_2(X,v-1) + H_2(X,w+1)$, as a function of the H₂ vibrational level.

In the present model, both the population inversion in the $H_2(X)$ VDF and the drop in the tail of the $N_2(X)$ VDF are due to the efficient V-V processes between both molecules (v8 and v9 in Table A1). As shown in Figure 16 for the monoquantum process, the V-V transfer with N_2 molecules in the lower vibrational states is most efficient for values of *v* around 8, which leads to a depletion of these vibrational levels in H_2 and an increment in the population of the upper levels. A similar effect occurs for the higher vibrational levels of $N_2(X)$, which are more efficiently destroyed by collisions with H_2 than the lower ones.

3.3 Main processes in the plasma chemistry

The purpose of this section is to identify the key mechanisms responsible for the creation and destruction of the major species present in the discharge. Tables 1, 2 and 3 show the normalized production and loss reaction rates of neutral, adsorbed and ionic species found in the plasma, respectively. They are calculated for a discharge at 0.92 mbar, 5% H_2 and 10 W, but similar to the NH₃ case, the main mechanisms are not expected to change substantially for most of the conditions studied. For brevity, only channels accounting for 5% or more of the total rate for each species are included in the tables.

		Production			Loss	
		Reaction	Rate		Reaction	Rate
N ₂ (X)		Inflow N ₂	0.88		Pumping	0.88
	n4	$N_2(A) + N_2(X, 5 \leq \nu \leq 14) \rightarrow N_2(B) + N_2(X, 0)$	0.07	n4	$N_2(A) + N_2(X, 5 {\leq} \nu {\leq} 14) \rightarrow N_2(B) + N_2(X, 0)$	0.07
H_2		Inflow H ₂	0.79		Pumping	0.75
	w7	$\mathrm{H} + \mathrm{H}(s) \longrightarrow \mathrm{H}_2 + \mathrm{F}$	0.20	n15	$N_2(a^\prime) + H_2(X) \rightarrow N_2(X) + 2H$	0.14
N(S)	e20	$e + N_2(X, v) \rightarrow e + N(S) + N(S)$	0.46	w2	$N + F \rightarrow N(s)$	0.27
	e21	$e + N_2(X, \nu) \rightarrow e + N(S) + N(D)$	0.25	w8	$N+N(s) \rightarrow N_2 + F$	0.21
	n1	$\begin{array}{l} N_2(X,11{\leq}\nu{\leq}24)+N_2(X,11{\leq}\nu{\leq}24) \rightarrow N_2(X,0)+\\ N(S)+N(S) \end{array}$	0.06	w9	$N + H(s) \rightarrow NH(s)$	0.14
	n21	$N(P) + N_2 \mathop{\longrightarrow} N(S) + N_2$	0.05	n33	$N(S) + NH_2 \mathop{\longrightarrow} N_2(X) + 2H$	0.13
	n44	$\mathrm{H} + \mathrm{NH} \rightarrow \mathrm{N}(\mathrm{S}) + \mathrm{H}_2(\mathrm{X})$	0.05	n32	$N(S) + NH \rightarrow N_2(X) + H$	0.13
	n5	$\begin{array}{l} N_2(A) + N_2(X, 14 \leq \nu \leq 19) \rightarrow N_2(X, 0) + N(S) + \\ N(S) \end{array}$	0.05	n6	$N_2(A) + N(S) \rightarrow N_2(X, 6 \leq \nu \leq 9) + N(P)$	0.09
Н	n15	$N_2(a') + H_2(X) \rightarrow N_2(X) + 2H$	0.53	w1	$H + F \rightarrow H(s)$	0.57
	n33	$N(S) + NH_2 \rightarrow N_2(X) + 2H$	0.13	w7	$\mathrm{H} + \mathrm{H}(\mathrm{s}) \to \mathrm{H}_2 + \mathrm{F}$	0.37
	e22	$e + H_2(X, v) \rightarrow e + 2H$	0.08			
	n32	$N(S) + NH \rightarrow N_2(X) + H$	0.06			
	im6	$N_{2^{+}} + H_{2} \longrightarrow N_{2}H^{+} + H \\$	0.05			
	n35	$N(D) + H_2(X) \rightarrow H + NH$	0.05			
NH ₃	w17	$H(s) + NH_2(s) \rightarrow NH_3 + 2F$	0.83	n36	$N(D) + NH_3 \rightarrow NH_2 + NH$	0.51
	w36	$NH_{4}{}^{+} + wall \longrightarrow NH_{3} + H$	0.12		Pumping	0.31
				im24	$N_2H^+ + NH_3 \longrightarrow NH_4^+ + N_2$	0.12

Table 1. Main production and loss processes for the major neutral species of the discharge, calculated for a discharge with 5% H₂, 0.92 mbar and 10 W. Rates are given as a fraction of the total production/loss of each species.

As expected, the main sources and losses for both precursor molecules, N_2 and H_2 , are related to the gas inflow into the reactor and the pumping (see Table 1). In both of these cases minor processes are also identified. In the

case of N_2 , it is a reaction with $N_2(A)$ that results in the conversion of vibrationally excited states to the ground state, resulting in no net change of the $N_2(X)$ density, but for H_2 , the wall recycling of H atoms is shown to be a relevant process, while the dissociation through reaction with $N_2(a')$ appears to be also an important mechanism.

Atoms are shown to have multiple significant mechanisms of creation and destruction. N(S) atoms are produced mostly by electron impact dissociation of N₂ and then lost to surface reactions, while, notably, H atoms are mostly created by the aforementioned reaction of H₂ with N₂(a'), with electron impact only accounting for $\sim 8\%$ of the total dissociation. They are then lost to surface reactions as well.

Finally, as was shown before, the main production channel of NH_3 is the Langmuir-Hinshelwood process involving H(s) and $NH_2(S)$, while it is lost is not only to pumping but also through reaction with N(D) metastables.

		Production			Loss	
		Reaction	Rate		Reaction	Rate
H(s)	w1	$H + F \rightarrow H(s)$	0.87	w7	$\mathrm{H} + \mathrm{H}(s) \longrightarrow \mathrm{H}_2 + \mathrm{F}$	0.56
	w6	$\mathrm{H_2} + \mathrm{2F} \rightarrow \mathrm{2H(s)}$	0.13	w17	$H(s) + NH_2(s) \rightarrow NH_3 + 2F$	0.17
				w16	$\mathrm{NH}(s) + \mathrm{H}(s) \to \mathrm{NH}_2(s) + \mathrm{F}$	0.16
				w9	$N + H(s) \rightarrow NH(s)$	0.11
N(s)	w2	$N + F \rightarrow N(s)$	0.99	w8	$N + N(s) \rightarrow N_2 + F$	0.78
				w10	$\mathrm{H} + \mathrm{N}(\mathrm{s}) \longrightarrow \mathrm{NH}(\mathrm{s})$	0.21
NH(s)	w9	$N + H(s) \rightarrow NH(s)$	0.66	w16	$\mathrm{NH}(s) + \mathrm{H}(s) \to \mathrm{NH}_2(s) + \mathrm{F}$	0.97
	w10	$H + N(s) \rightarrow NH(s)$	0.27			
	w3	$\rm NH + F \rightarrow \rm NH(s)$	0.07			
NH ₂ (s)	w16	$NH(s) + H(s) \rightarrow NH_2(s) + F$	0.94	w17	$H(s) + NH_2(s) \rightarrow NH_3 + 2F$	1.00

Table 2. Same as Table 1, but for the adsorbed species at the reactor walls.

Surface chemistry, which is shown in Table 2, is somewhat simpler than the neutral chemistry previously analyzed. The hydrogen and nitrogen atoms adsorbed at the surface are mostly originating from atoms in the gas phase, and then a small number of reactions can happen from that point. The most favorable ones in our surface seems to be the recycling of the atoms into the precursors N_2 and H_2 , however, NH can also be formed from both adsorbed atoms. The next two reactions are quite straightforward, with $NH_2(s)$ being formed by surface association of H(s) and NH(s) and the final production of NH_3 , which is the only possible loss mechanism for $NH_2(s)$.

Table 3. Same as Ta	ble 1, but for the	main ions in the	plasma
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		Production			Loss	
		Reaction	Rate		Reaction	Rate
N_{2}^{+}	e28	$e + N_2(X,0) \rightarrow N_2^+ + 2e$	1.00	im6	$N_{2^{+}} + H_{2} \longrightarrow N_{2}H^{+} + H$	0.85
				w26	$N_{2^{+}} + wall \rightarrow N_{2}$	0.12
N_2H^+	im6	$N_2{}^+ + H_2 \mathop{\longrightarrow} N_2 H^+ + H$	0.93	w32	$N_2H^+ + wall \longrightarrow H + N_2$	0.75
	im18	$H_2{}^+ + N_2 \mathop{\longrightarrow} N_2 H^+ + H$	0.06	im24	$N_2H^+ + NH_3 \longrightarrow NH_4^+ + N_2$	0.25
NH4 ⁺	im24	$N_2H^+ + NH_3 \longrightarrow NH_4^+ + N_2$	0.96	w36	$NH_{4^{+}} + wall \rightarrow NH_{3} + H$	0.98
NH ₃ ⁺	im7	$N_{2^{+}} + NH_{3} \rightarrow NH_{3^{+}} + N_{2} \\$	0.77	w35	$\rm NH_{3^+} + wall \rightarrow \rm NH_{3}$	0.77
	e43	$e + NH_3 \longrightarrow NH_3^+ + 2e$	0.20	im32	$NH_{3^{+}} + NH_{3} \longrightarrow NH_{2} + NH_{4^{+}}$	0.23

H⁻	im36	$NH_2^- + H_2 \longrightarrow NH_3 + H^-$	0.52	ii5	$H^- + NH_4^+ \longrightarrow NH_3 + H_2$	0.56
	e48	$e + NH_3 \longrightarrow NH_2 + H^-$	0.46	im34	$H^- + H \longrightarrow H_2 + e$	0.43
NH ₂ ⁻	e47	$e + NH_3 \longrightarrow NH_2^- + H$	1.00	im36	$NH_2^- + H_2 \longrightarrow NH_3 + H^-$	0.98

The chemistry of the major positive ions in the discharge is also relatively simple and dominated by a handful of processes, as shown in Table 3. The main reactions accounting for a net production of charge are the ionization of N_2 and NH_3 , which act as the start of a chain of hydrogenation reactions. N_2^+ is then lost through reaction with hydrogen to N_2H^+ , which can then react with NH_3 to form NH_4^+ . In the case of NH_3^+ , it can directly react with NH_3 to also give NH_4^+ . However, the NH_4^+ ion does not react with neutrals in the gas phase, instead being lost mainly to the reactor walls, which explains the large density of this ion found in the simulations. No other species is involved in this group of reactions besides those mentioned above, which might explain why this specific group of ions was so well reproduced in the comparison with the experiments of Figures 7 and 8.

Finally, the negative ions (NH_2^-, H^-) in the discharge also follow a simple chemistry. Both are formed by dissociative attachment of NH_3 , but NH_2^- can also be converted to H^- through collisions with H_2 , which explains why H^- is the most abundant of the two.

Conclusions

Capacitively coupled discharges in N_2 - H_2 mixtures with hydrogen concentrations up to 5% have been studied by means of a hybrid code that couples a two-dimensional time-dependent fluid-type module, describing the transport of the charged particles, to a very complete zero-dimensional kinetic module for the nitrogen-hydrogen mixture. The results of the simulations have been compared to the experimental measurements described in paper I.

The electrical parameters obtained from the model are in good agreement with the measurements. To capture the behavior of the electron density with growing power, a module devoted to the simulation of the fast electrons generated by secondary emission must be included in the model. The inclusion of these fast electrons results in an exponential growth of the electron density at higher powers, which cannot be accounted for by the fluid code for slow electrons, and which can be fitted to the experimental values by tuning the secondary emission coefficient γ . A comparison between the slow and fast electrons in the model shows that, while both groups are responsible for ionization in the sheaths, fast electrons are present in the discharge bulk with high energies and produce ionizations in this region far more effectively than the slow electrons, which results in the observed increase in the electron density.

Ion fluxes to the reactor walls obtained from the simulations have been compared to the QMS measurements for charged particles. The ion distribution obtained experimentally is found to correspond to a high electron energy condition similar to the one obtained with the model for the sheath region. Further comparison of the ion fluxes in this region with the experiments shows a good agreement in the fluxes of the major positive ions in the discharge (N_2^+, N_2H^+, NH_4^+) , which also follow the experimental trends when varying the H₂ fraction, the pressure and the coupled power. However, the behavior of the minor ions in the discharge showed some discrepancies between model and experiment. Ion fluxes are also shown not to be representative of the actual ion composition of the discharge, due to the different distribution of ions in the sheath and in the bulk.

Ion and neutral chemistry are found to be heavily influenced by the formation of NH_3 at the reactor walls. The comparison between the predicted NH_3 fraction and the experimental one implies that the surface reactivity of the chamber must be significantly low compared to the one for stainless steel. With this lower reactivity, the trends of the NH_3 fraction as a function of H_2 , pressure, and power are correctly reproduced, although the quantitative agreement could be improved. The analysis of the different formation mechanisms of NH_3 evinces that surface reactions are largely responsible for its formation, and only at large powers is ion neutralization a somewhat competing mechanism.

A significant effect of hydrogen addition is also observed in the vibrational distributions of N_2 and H_2 . The populations of the higher vibrational levels are found to be especially sensitive to collisions between the two species, resulting in a decrease of the VDF tail with growing H_2 .

The main production and loss processes for the major species in the plasma were extracted from the model. Neutral chemistry was found to be more complex than heterogeneous and ionic chemistry, where only a few reactions were responsible for the final distributions obtained from the simulations.

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Appendix

Table A1. Complete set of reactions included in the model. Rate coefficients are given in cm³ s⁻¹, except for three body reactions (cm⁶ s⁻¹) and emission rates (s⁻¹). Sticking and recombination coefficients are non-dimensional; E_{LH} is given in eV; T_g is given in K. The label *f*(*E*/*N*) means that the rate coefficient was obtained by integration of the corresponding cross section over the EEDF, self-consistently calculated by the model.

Vibrational processes

	_		
v1	e–V	$e + N_2(X, v) \leftrightarrow e + N_2(X, w)$; $v=0-9$; $w=(v+1)-10$	[66,71]
v2	V–T	$N_2(X,v) + N_2 \rightarrow N_2(X,w) + N_2$	[60]
v3	V–V	$N_2(X,v) + N_2(X,w) \rightarrow N_2(X,v+1) + N_2(X,w-1)$	[60]
v4		$N_2(X,v) + wall \rightarrow N_2(X,v-1)$	[60]
v5	V–T	$N_2(X, v) + H_2 \rightarrow N_2(X, w) + H_2$	[52]
v6	V–T	$N_2(X,v) + N \rightarrow N_2(X,w) + N$	[52]
v7	V–T	$N_2(X,v) + H \rightarrow N_2(X,w) + H$	[52]
v8	V–V	$N_2(X,\nu) + H_2(X,w) \leftrightarrow N_2(X,\nu+1) + H_2(X,w-1)$	[52]
v9	V–V	$N_2(X,\nu) + H_2(X,w) \leftrightarrow N_2(X,\nu+2) + H_2(X,w-1)$	[52]
v10	e–V	$e + H_2(X, \nu) \leftrightarrow e + H_2(X, \nu+i); \nu=0-13; i=1-3$	[66]
v11	V–T	$\mathrm{H}_2(\mathrm{X}, \nu) + \mathrm{H}_2 \longrightarrow \mathrm{H}_2(\mathrm{X}, w) + \mathrm{H}_2$	[61]
v12	V–T	$H_2(X,v) + H \rightarrow H_2(X,w) + H$	[52]
v13	V–V	$\mathrm{H}_2(\mathrm{X}, \nu) + \mathrm{H}_2(\mathrm{X}, w) \leftrightarrow \mathrm{H}_2(\mathrm{X}, \nu + 1) + \mathrm{H}_2(\mathrm{X}, w - 1)$	[61]
v14		$H_2(X,\nu) + wall \rightarrow H_2(X,\nu-1)$	[61]
v15	E-V	$e + H_2(X,v) \rightarrow e + H_2(B,C) \rightarrow e + H_2(X,w)$	[61,66]

Electron impact processes

Excitation	on and deexcitation	Rate coefficient	Ref.
e1	$e + N_2(X,0) \rightarrow e + N_2(A)$	f(E/N)	[66]
e2	$e + N_2(X,0) \rightarrow e + N_2(B)$	f(E/N)	[66]
e4	$e + N_2(X,0) \rightarrow e + N_2(B')$	f(E/N)	[66]

e3	$e + N_2(X,0) \rightarrow e + N_2(C)$	f(E/N)	[66]
e5	$e + N_2(X,0) \rightarrow e + N_2(a')$	f(E/N)	[66]
еб	$e + N_2(X,0) \rightarrow e + N_2(a)$	f(E/N)	[66]
e7	$e + N_2(X,0) \rightarrow e + N_2(w)$	f(E/N)	[66]
e8	$e + N_2(X,0) \rightarrow e + N_2(a")$	f(E/N)	[66]
e9	$e + N_2(A) \rightarrow e + N_2(X,0)$	f(E/N)	[66]
e10	$e + N_2(A) \rightarrow e + N_2(B)$	f(E/N)	[66]
e11	$e + N_2(A) \rightarrow e + N_2(C)$	f(E/N)	[66]
e12	$e + N_2(B) \rightarrow e + N_2(A)$	f(E/N)	[66]
e13	$e + N_2(C) \rightarrow e + N_2(A)$	f(E/N)	[66]
e14	$e + N(S) \rightarrow e + N(D)$	f(E/N)	[66]
e15	$e + N(S) \rightarrow e + N(P)$	f(E/N)	[66]
e16	$e + N(D) \rightarrow e + N(S)$	f(E/N)	[66]
e17	$e + N(D) \rightarrow e + N(P)$	f(E/N)	[66]
e18	$e + N(P) \rightarrow e + N(S)$	f(E/N)	[66]
e19	$e + N(P) \rightarrow e + N(D)$	f(E/N)	[66]
Dissoc	iation	Rate coefficient	
e20	$e + N_2(X, \nu) \rightarrow e + N(S) + N(S)$	f(E/N)	[60]
e21	$e + N_2(X, \nu) \rightarrow e + N(S) + N(D)$	f(E/N)	[60]
e22	$e + H_2(X, \nu) \rightarrow e + 2H$	f(E/N)	[66]
e23	$e + NH \rightarrow N + H + e$	f(E/N)	[65,83]
e24	$e + NH_2 {\rightarrow} N + H_2 + e$	f(E/N)	[65,83]
e25	$e + NH_2 \longrightarrow NH + H + e$	f(E/N)	[65,83]
e26	$e + NH_3 {\rightarrow} NH_2 + H + e$	f(E/N)	[83]
e27	$e + NH_3 {\rightarrow} NH + H_2 + e$	f(E/N)	[83]
Ionizat	ion	Rate coefficient	
e28	$e + N_2(X,0) \rightarrow N_2^+ + 2e$	f(F/N)	[66]
		J(E/1V)	[00]
e29	$e + N_2(X,0) \rightarrow N^+ + N + 2e$	f(E/N)	[66,88]
e29 e30	$e + N_2(X,0) \rightarrow N^+ + N + 2e$ $e + N_2(A) \rightarrow N_2^+ + 2e$	f(E/N) f(E/N)	[66,88] [66]
e29 e30 e31	$e + N_2(X,0) \rightarrow N^+ + N + 2e$ $e + N_2(A) \rightarrow N_2^+ + 2e$ $e + N_2(B) \rightarrow N_2^+ + 2e$	f(E/N) f(E/N) f(E/N)	[66] [66] [66]
e29 e30 e31 e32	$\begin{split} &e + N_2(X,0) \rightarrow N^+ + N + 2e \\ &e + N_2(A) \rightarrow N_2^+ + 2e \\ &e + N_2(B) \rightarrow N_2^+ + 2e \\ &e + N_2(a') \rightarrow N_2^+ + 2e \end{split}$	f(E/N) $f(E/N)$ $f(E/N)$ $f(E/N)$	[66] [66] [66] [66]
e29 e30 e31 e32 e33	$e + N_2(X,0) \rightarrow N^+ + N + 2e$ $e + N_2(A) \rightarrow N_2^+ + 2e$ $e + N_2(B) \rightarrow N_2^+ + 2e$ $e + N_2(a') \rightarrow N_2^+ + 2e$ $e + N_2(a) \rightarrow N_2^+ + 2e$	f(E/N) $f(E/N)$ $f(E/N)$ $f(E/N)$ $f(E/N)$	[66] [66] [66] [66] [66]
e29 e30 e31 e32 e33 e34	$\begin{split} & e + N_2(X,0) \to N^+ + N + 2e \\ & e + N_2(A) \to N_2^+ + 2e \\ & e + N_2(B) \to N_2^+ + 2e \\ & e + N_2(a') \to N_2^+ + 2e \\ & e + N_2(a) \to N_2^+ + 2e \\ & e + N_2(w) \to N_2^+ + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66]
e29 e30 e31 e32 e33 e34 e35	$\begin{split} & e + N_2(X,0) \to N^+ + N + 2e \\ & e + N_2(A) \to N_2^+ + 2e \\ & e + N_2(B) \to N_2^+ + 2e \\ & e + N_2(a') \to N_2^+ + 2e \\ & e + N_2(a) \to N_2^+ + 2e \\ & e + N_2(w) \to N_2^+ + 2e \\ & e + H_2 \to H_2^+ + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66] [66]
 e29 e30 e31 e32 e33 e34 e35 e36 	$\begin{split} & e + N_2(X,0) \to N^+ + N + 2e \\ & e + N_2(A) \to N_2^+ + 2e \\ & e + N_2(B) \to N_2^+ + 2e \\ & e + N_2(a') \to N_2^+ + 2e \\ & e + N_2(a) \to N_2^+ + 2e \\ & e + N_2(w) \to N_2^+ + 2e \\ & e + H_2 \to H_2^+ + 2e \\ & e + H_2 \to H_2^+ + H_2 + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66] [66,89] [66,89]
e29 e30 e31 e32 e33 e34 e35 e36 e37	$\begin{split} e + N_2(X,0) &\to N^+ + N + 2e \\ e + N_2(A) &\to N_2^+ + 2e \\ e + N_2(B) &\to N_2^+ + 2e \\ e + N_2(a') &\to N_2^+ + 2e \\ e + N_2(a) &\to N_2^+ + 2e \\ e + N_2(w) &\to N_2^+ + 2e \\ e + H_2 &\to H_2^+ + 2e \\ e + H_2 &\to H^+ + H + 2e \\ e + H_2 &\to N^+ + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66,89] [66,89] [66,89]
 e29 e30 e31 e32 e33 e34 e35 e36 e37 e38 	$\begin{split} e + N_2(X,0) &\to N^+ + N + 2e \\ e + N_2(A) &\to N_2^+ + 2e \\ e + N_2(B) &\to N_2^+ + 2e \\ e + N_2(a') &\to N_2^+ + 2e \\ e + N_2(a) &\to N_2^+ + 2e \\ e + N_2(w) &\to N_2^+ + 2e \\ e + H_2 &\to H_2^+ + 2e \\ e + H_2 &\to H^+ + H + 2e \\ e + H &\to M^+ + 2e \\ e + H &\to M^+ + 2e \\ e + H &\to H^+ + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66,89] [66,89] [66] [66]
 e29 e30 e31 e32 e33 e34 e35 e36 e37 e38 e39 	$\begin{split} e + N_2(X,0) &\to N^+ + N + 2e \\ e + N_2(A) &\to N_2^+ + 2e \\ e + N_2(B) &\to N_2^+ + 2e \\ e + N_2(a') &\to N_2^+ + 2e \\ e + N_2(a) &\to N_2^+ + 2e \\ e + N_2(w) &\to N_2^+ + 2e \\ e + H_2 &\to H_2^+ + 2e \\ e + H_2 &\to H^+ + H + 2e \\ e + H &\to N^+ + 2e \\ e + H &\to M^+ + 2e \\ e + H &\to M^+ + 2e \\ e + NH &\to NH^+ + 2e \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66] [66,89] [66,89] [66] [66] [60]
e29 e30 e31 e32 e33 e34 e35 e36 e37 e38 e39 e40	$\begin{split} e + N_2(X,0) &\to N^+ + N + 2e \\ e + N_2(A) &\to N_2^+ + 2e \\ e + N_2(B) &\to N_2^+ + 2e \\ e + N_2(a') &\to N_2^+ + 2e \\ e + N_2(a) &\to N_2^+ + 2e \\ e + N_2(w) &\to N_2^+ + 2e \\ e + H_2 &\to H_2^+ + 2e \\ e + H_2 &\to H^+ + H + 2e \\ e + H &\to N^+ + 2e \\ e + H &\to N^+ + 2e \\ e + NH &\to NH^+ + 2e \\ e + NH &\to NH^+ + H + 2e \\ \end{split}$	f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N) f(E/N)	[66] [66] [66] [66] [66] [66] [66,89] [66,89] [66] [66] [90] [90]

e42	$e + NH_2 \rightarrow NH^+ + H + 2e$	f(E/N)	[90]
e43	$e + NH_3 \rightarrow NH_3^+ + 2e$	f(E/N)	[83]
e44	$e + NH_3 \rightarrow NH_2{}^+ + H + 2e$	f(E/N)	[83,91]
e45	$e + NH_3 \rightarrow NH^+ + H_2 + 2e$	f(E/N)	[83,91]
e46	$e + NH_3 \longrightarrow N^+ + H_2 + H + 2e$	f(E/N)	[83,91]
e47	$e + NH_3 \rightarrow H^+ + NH_2 + 2e$	f(E/N)	[83,91]
Attach	nent and detachment	Rate coefficient	
e45	$e + H_2 \rightarrow H + H^-$	f(E/N)	[92]
e46	$e + NH_2 \longrightarrow NH + H^-$	f(E/N)	[83,93]
e47	$e + NH_3 \rightarrow NH_2^- + H$	f(E/N)	[83,93]
e48	$e + NH_3 \rightarrow NH_2 + H^-$	f(E/N)	[83,93]
e49	$e + H^- \rightarrow H + 2e$	f(E/N)	[94]
Neutra	lization	Rate coefficient	
e50	$e + N^{\scriptscriptstyle +} \to N$	f(E/N)	[65]
e51	$e + N_2^+ {\longrightarrow} N + N$	f(E/N)	[60]
e52	$e + {N_3}^+ {\rightarrow} N_2 + N$	f(E/N)	[71]
e53	$e + N_4^+ {\longrightarrow} N_2 + N_2$	f(E/N)	[60]
e54	$e + H^+ \longrightarrow H$	f(E/N)	[95]
e55	$e + {H_2}^+ {\rightarrow} H + H$	f(E/N)	[95]
e56	$e + H_{3}^{+} \longrightarrow H_{2} + H$	f(E/N)	[95]
e57	$e + N_2 H^+ \mathop{\longrightarrow} N_2 + H$	f(E/N)	[49]
e58	$e + NH^+ \longrightarrow N + H$	f(E/N)	[49]
e59	$e + NH_{2^{+}} {\rightarrow} N + 2H$	f(E/N)	[49]
e60	$e + NH_{2}^{+} \longrightarrow NH + H$	f(E/N)	[49]
e61	$e + NH_{3^+} \rightarrow NH + 2H$	f(E/N)	[49]
e62	$e + NH_{3^+} {\longrightarrow} NH_2 + H$	f(E/N)	[49]
e63	$e + NH_4^+ \mathop{\longrightarrow} NH_2 + 2H$	f(E/N)	[49]
e64	$e + NH_{4^+} \mathop{\longrightarrow} NH_3 + H$	f(E/N)	[49]

Neutral-neutral processes

Collisior	al excitation and deexcitation	Rate coefficient	
n1	$N_2(X,11 {\leq} \nu {\leq} 24) + N_2(X,11 {\leq} \nu {\leq} 24) \rightarrow N_2(X,0) + N(S) + N(S)$	3.50×10 ⁻¹⁵	[60]
n2	$N_2(A) + N_2(A) \rightarrow N_2(B) + N_2(X,0)$	7.7×10^{-11}	[60]
n3	$N_2(A) + N_2(A) \rightarrow N_2(C) + N_2(X,0)$	1.50×10^{-10}	[60]
n4	$N_2(A) + N_2(X,5{\leq}\nu{\leq}14) \to N_2(B) + N_2(X,0)$	2.0×10 ⁻¹¹	[60]
n5	$N_2(A) + N_2(X, 14 {\leq} \nu {\leq} 19) \rightarrow N_2(X, 0) + N(S) + N(S)$	1.5×10^{-12}	[60]
n6	$N_2(A) + N(S) \rightarrow N_2(X, 6 {\leq} \nu {\leq} 9) + N(P)$	4.0×10 ⁻¹¹	[60]
n7	$N_2(A) + H \rightarrow N_2(X,0) + H$	5.0×10 ⁻¹¹	[52]
n8	$N_2(A) + H_2 \rightarrow N_2(X) + 2H$	$2.0 \times 10^{-10} \times \exp(-3500/T_g)$	[52]
n9	$N_2(A) + NH_3 \rightarrow N_2(X,0) + NH_3$	1.6×10^{-10}	[52]

n10	$N_2(B)+N_2 \longrightarrow N_2(A)+N_2$	$0.95 \times 3.0 \times 10^{-11}$	[60]
n11	$N_2(B)+N_2 \rightarrow N_2(X,0)+N_2$	$0.05 \times 3.0 \times 10^{-11}$	[60]
n12	$N_2(B) + H_2 \longrightarrow N_2(A) + H_2$	2.5×10 ⁻¹¹	[52]
n13	$N_2(a^\prime) + N_2 \longrightarrow N_2(B) + N_2$	1.90×10^{-13}	[60]
n14	$\mathrm{N_2(a')} + \mathrm{H} \rightarrow \mathrm{N_2(X,0)} + \mathrm{H}$	1.5×10 ⁻¹¹	[52]
n15	$N_2(a') + H_2(X) \rightarrow N_2(X) + 2H$	2.6×10 ⁻¹¹	[52]
n16	$N_2(a) + N_2 \rightarrow N_2(a') + N_2$	2.0×10 ⁻¹¹	[60]
n17	$N_2(w) + N_2 \longrightarrow N_2(a) + N_2$	1.0×10 ⁻¹¹	[60]
n18	$N_2(a'') + N_2 \rightarrow products$	2.3×10 ⁻¹⁰	[60]
n19	$N(S) + N(S) + N_2 \rightarrow N_2(B) + N_2$	$8.27 \times 10^{-34} \exp(500/T_g)$	[60]
n20	$N(D) + N_2 \rightarrow N(S) + N_2$	$1.0 \times 10^{-13} \exp(-510/T_g)$	[60]
n21	$N(P) + N_2 \mathop{\longrightarrow} N(S) + N_2$	6.0×10^{-14}	[60]
n22	$N(P) + N_2(X,\nu{\geq}10) \rightarrow N(S) + N_2(A)$	$1.0 \times 10^{-10} \exp(-1300/T_g)$	[60]
n23	$N(P) + N(S) \rightarrow N(S) + N(S)$	1.2×10^{-12}	[60]
n24	$N(P) + N(S) \rightarrow N(S) + N(D)$	6.0×10 ⁻¹³	[60]
Penning	ionization	Rate coefficient	
n26	$N_2(A) + N_2(a') \longrightarrow N_4{}^+ + e$	$0.5 \times 1.0 \times 10^{-11}$	[60]
n27	$N_2(A) + N_2(a') \to N_2(X,0) + N_2^+ + e$	$0.5 \times 1.0 \times 10^{-11}$	[60]
n28	$N_2(a') + N_2(a') \longrightarrow N_{4^+} + e$	$0.5 \times 5.0 \times 10^{-11}$	[60]
n29	$N_2(a') + N_2(a') \rightarrow N_2(X,0) + N_2^+ + e$	$0.5 \times 5.0 \times 10^{-11}$	[60]
n30	$N(D) + N(P) \rightarrow N_2{}^+ + e$	1.0×10 ⁻¹³	[60]
n30 n31	$\begin{split} N(D) + N(P) &\rightarrow N_2^+ + e \\ N_2(a') + N(P) &\rightarrow N_3^+ + e \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹	[60] [71]
n30 n31 Neutral-	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \end{split}$ neutral reactions	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient	[60] [71]
n30 n31 Neutral- n32	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \end{split}$ neutral reactions $\begin{split} N(S) + NH &\rightarrow N_{2}(X) + H \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹	[60] [71] [52]
n30 n31 Neutral- n32 n33	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \end{split}$ neutral reactions $\begin{split} N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰	[60] [71] [52] [52]
n30 n31 Neutral- n32 n33 n34	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X,\nu) &\rightarrow H + NH \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v,T_g)$	[60] [71] [52] [52] [52]
n30 n31 Neutral- n32 n33 n34 n35	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X,\nu) &\rightarrow H + NH \\ \hline N(D) + H_{2}(X) &\rightarrow H + NH \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v, T_{g})$ 2.3×10^{-12}	[60] [71] [52] [52] [52] [52]
n30 n31 Neutral- n32 n33 n34 n35 n36	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a^{*}) + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X,\nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v,T_g)$ 2.3×10^{-12} 1.1×10^{-10}	[60] [71] [52] [52] [52] [52] [52]
n30 n31 Neutral- n32 n33 n34 n35 n36 n37	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v,T_g)$ 2.3×10^{-12} 1.1×10^{-10} 2.5×10^{-14}	[60] [71] [52] [52] [52] [52] [52] [52]
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a^{*}) + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + M &\rightarrow N_{2} + M \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_s)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_s)	[60] [71] [52] [52] [52] [52] [52] [52] [52]
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a^{*}) + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X,\nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N+N + M &\rightarrow N_{2} + M \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v,T_g)$ 2.3×10^{-12} 1.1×10^{-10} 2.5×10^{-14} $8.3 \times 10^{-34} \exp(500/T_g)$ $5.4 \times 10^{-11} \exp(-6492/T_g)$	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + N + M &\rightarrow NH_{2} + M \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v, T_g)$ 2.3×10^{-12} 1.1×10^{-10} 2.5×10^{-14} $8.3 \times 10^{-34} \exp(500/T_g)$ $5.4 \times 10^{-11} \exp(-6492/T_g)$ 1.0×10^{-36}	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a^{*}) + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline n(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH + M &\rightarrow NH_{3} + M \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v, T_g)$ 2.3×10^{-12} 1.1×10^{-10} 2.5×10^{-14} $8.3 \times 10^{-34} \exp(500/T_g)$ $5.4 \times 10^{-11} \exp(-6492/T_g)$ 1.0×10^{-36} $2.5 \times 10^{-35} (T_g/300)^{2.63} \exp(1700/T_g)$	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N + N + M &\rightarrow N_{2} + M \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH + M &\rightarrow NH_{3} + M \\ H_{2} + NH + M &\rightarrow NH_{3} + M \\ H_{2} + NH + M &\rightarrow H_{2} + M \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_g)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_g) 5.4×10 ⁻¹¹ exp(-6492/ T_g) 1.0×10 ⁻³⁶ 2.5×10 ⁻³⁵ (T_g /300) ^{2.63} exp(1700/ T_g) 8.3×10 ⁻³³ (300/ T_g)	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42 n43	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \end{split}$ neutral reactions $\hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH_{2} &\rightarrow NH_{3} + M \\ H_{2} + NH + M &\rightarrow NH_{3} + M \\ H + H + M &\rightarrow NH + M \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_g)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_g) 5.4×10 ⁻¹¹ exp(-6492/ T_g) 1.0×10 ⁻³⁶ 2.5×10 ⁻³⁵ (T_g /300) ^{2.63} exp(1700/ T_g) 8.3×10 ⁻³³ (300/ T_g) 5.0×10 ⁻³²	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42 n43 n44	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a^{*}) + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline neutral reactions \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH &\rightarrow NH_{2} + M \\ H_{2} + NH + M &\rightarrow NH_{3} + M \\ H + H + M &\rightarrow NH + M \\ H + NH &\rightarrow N(S) + H_{2}(X) \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_g)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_g) 5.4×10 ⁻¹¹ exp(-6492/ T_g) 1.0×10 ⁻³⁶ 2.5×10 ⁻³⁵ (T_g /300) ^{2.63} exp(1700/ T_g) 8.3×10 ⁻³³ (300/ T_g) 5.0×10 ⁻³² 5.4×10 ⁻¹¹ exp(-165/ T_g)	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42 n43 n44 n45	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \end{split}$ neutral reactions $\hline N(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N + N + M &\rightarrow N_{2} + M \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH &\rightarrow NH_{2} + M \\ H_{2} + NH + M &\rightarrow NH_{2} + M \\ H_{2} + NH + M &\rightarrow NH_{3} + M \\ H + H + M &\rightarrow NH + M \\ H + NH &\rightarrow N(S) + H_{2}(X) \\ H + NH_{2} &\rightarrow H_{2}(X) + NH \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_g)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_g) 5.4×10 ⁻¹¹ exp(-6492/ T_g) 1.0×10 ⁻³⁶ 2.5×10 ⁻³⁵ (T_g /300) ^{2.63} exp(1700/ T_g) 8.3×10 ⁻³³ (300/ T_g) 5.0×10 ⁻³² 5.4×10 ⁻¹¹ exp(-165/ T_g) 6.6×10 ⁻¹¹ exp(-1840/ T_g)	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42 n43 n44 n45 n46	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline neutral reactions \\ \hline n(S) + NH &\rightarrow N_{2}(X) + H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ N(D) + H_{2}(X) &\rightarrow H + NH \\ N(D) + NH_{3} &\rightarrow NH_{2} + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N(P) + H_{2}(X) &\rightarrow H + NH \\ N + N + M &\rightarrow N_{2} + M \\ H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ H_{2} + NH &\rightarrow NH_{3} + M \\ H_{2} + NH &\rightarrow NH_{3} + M \\ H + H + M &\rightarrow NH + M \\ H + NH &\rightarrow N(S) + H_{2}(X) \\ H + NH_{2} &\rightarrow H_{3} + M \\ \end{split}$	1.0×10 ⁻¹³ 10 ⁻¹¹ Rate coefficient 5.0×10 ⁻¹¹ 1.2×10 ⁻¹⁰ $f(v,T_g)$ 2.3×10 ⁻¹² 1.1×10 ⁻¹⁰ 2.5×10 ⁻¹⁴ 8.3×10 ⁻³⁴ exp(500/ T_g) 5.4×10 ⁻¹¹ exp(-6492/ T_g) 1.0×10 ⁻³⁶ 2.5×10 ⁻³⁵ (T_g /300) ^{2.63} exp(1700/ T_g) 8.3×10 ⁻³³ (300/ T_g) 5.0×10 ⁻³² 5.4×10 ⁻¹¹ exp(-165/ T_g) 6.6×10 ⁻¹¹ exp(-1840/ T_g) 5.5×10 ⁻³⁰	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52
n30 n31 Neutral- n32 n33 n34 n35 n36 n37 n38 n39 n40 n41 n42 n43 n44 n45 n46 n47	$\begin{split} N(D) + N(P) &\rightarrow N_{2}^{+} + e \\ \hline N_{2}(a') + N(P) &\rightarrow N_{3}^{+} + e \\ \hline \\ \hline neutral reactions \\ \hline \\ \hline N(S) + NH &\rightarrow N_{2}(X) + H \\ \hline N(S) + NH_{2} &\rightarrow N_{2}(X) + 2H \\ \hline N(S) + H_{2}(X, \nu) &\rightarrow H + NH \\ \hline N(D) + H_{2}(X) &\rightarrow H + NH \\ \hline N(D) + H_{2}(X) &\rightarrow H + NH \\ \hline N(D) + H_{2}(X) &\rightarrow H + NH \\ \hline N(P) + H_{2}(X) &\rightarrow H + NH \\ \hline N(P) + H_{2}(X) &\rightarrow H + NH \\ \hline H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ \hline H_{2} + NH_{2} &\rightarrow NH_{3} + H \\ \hline H_{2} + NH + M &\rightarrow NH_{2} + M \\ \hline H_{2} + NH + M &\rightarrow NH_{3} + M \\ \hline H + H + M &\rightarrow NH + M \\ \hline H + NH &\rightarrow N(S) + H_{2}(X) \\ \hline H + NH_{2} &\rightarrow H_{2}(X) + NH \\ \hline H + NH_{2} &\rightarrow M_{3} + M \\ \hline H + NH_{2} &\rightarrow M_{3} + M \\ \hline H + NH_{2} &\rightarrow M_{3} + M \\ \hline H + NH_{2} &\rightarrow M_{2}(X) + NH \\ \hline H + NH_{3} &\rightarrow H_{2}(X) + NH_{2} \end{split}$	1.0×10^{-13} 10^{-11} Rate coefficient 5.0×10^{-11} 1.2×10^{-10} $f(v, T_g)$ 2.3×10^{-12} 1.1×10^{-10} 2.5×10^{-14} $8.3 \times 10^{-34} \exp(500/T_g)$ $5.4 \times 10^{-11} \exp(-6492/T_g)$ 1.0×10^{-36} $2.5 \times 10^{-35} (T_g/300)^{2.63} \exp(1700/T_g)$ $8.3 \times 10^{-33} (300/T_g)$ 5.0×10^{-32} $5.4 \times 10^{-11} \exp(-165/T_g)$ $6.6 \times 10^{-11} \exp(-1840/T_g)$ 5.5×10^{-30} $8.4 \times 10^{-14} \exp(-4760/T_g) (T_g/300)^{4.1}$	[60] [71] [52] [52] [52] [52] [52] [52] [52] [52

n49	$\rm NH + \rm NH \rightarrow \rm N(S) + \rm NH_2$	$1.7 \times 10^{-12} (T_g/300)^{1.5}$	[52]
n50	$\rm NH + \rm NH \rightarrow \rm 2H + \rm N_2(\rm X)$	8.5×10 ⁻¹¹	[52]
n51	$\rm NH + \rm NH \rightarrow \rm N_2H_2$	3.5×10 ⁻¹²	[65]
n52	$\rm NH + \rm NH_2 \rightarrow \rm N(S) + \rm NH_3$	1.66×10^{-12}	[52]
n53	$NH + NH_2 \rightarrow H + N_2H_2$	$2.5 \times 10^{-9} (300/T_g)^{0.5}$	[65]
n54	$NH + NH_2 \rightarrow N_2H_3$	1.2×10^{-10}	[65]
n55	$NH + NH_3 + M \rightarrow N_2H_4 + M \\$	4.0×10 ⁻³⁵	[65]
n56	$NH + NH_3 + NH_3 \rightarrow N_2H_4 + NH_3$	1.0×10 ⁻³³	[65]
n57	$NH_2 + NH_2 \rightarrow N_2H_2 + H_2$	1.3×10 ⁻¹²	[65]
n58	$\rm NH_2 + \rm NH_2 \rightarrow \rm NH_3 + \rm NH$	$1.8 \times 10^{-14} (T_g/300)^{2.79} \exp(-660/T_g)$	[65]
n59	$NH_2 + NH_2 + NH_3 \longrightarrow N_2H_4 + NH_3$	6.9×10 ⁻³⁰	[65]
n60	$N_2H_2+H \longrightarrow N_2+H_2+H$	$4.5 \times 10^{-13} (T_g/300)^{2.63} \exp(115/T_g)$	[65]
n61	$N_2H_2 + NH_2 \rightarrow N_2 + H + NH_3$	$1.5 \times 10^{-13} (T_g/300)^{4.05} \exp(810/T_g)$	[65]
n62	$N_2H_3 + H \rightarrow NH_2 + NH_2$	2.7×10 ⁻¹²	[65]
n63	$N_2H_3 + N_2H_3 \rightarrow NH_3 + NH_3 + N_2$	5.0×10 ⁻¹²	[65]
n64	$N_2H_3 + N_2H_3 \rightarrow N_2H_4 + N_2H_2$	2.0×10 ⁻¹¹	[65]
n65	$N_2H_4 + H \rightarrow N_2H_3 + H_2$	$1.2 \times 10^{-11} \exp(-1260/T_g)$	[65]
n66	$N_2H_4 + N \rightarrow N_2H_2 + NH_2$	1.3×10 ⁻¹³	[65]
n67	$N_2H_4 + NH_2 \longrightarrow N_2H_3 + NH_3$	5.2×10 ⁻¹³	[65]

Ion-mol	ecule reactions	Rate coefficient	
im1	$\rm N^+ + \rm H \longrightarrow \rm N + \rm H^+$	2.0×10 ⁻⁹	[65]
im2	$N^+ + H_2 \longrightarrow H + N H^+$	5.6×10 ⁻¹⁰	[65]
im3	$N^+ + M \rightarrow N + M^+ M = NH_2, NH_3$	2.4×10 ⁻⁹	[65]
im4	$N^+ + N_2 + N_2 \longrightarrow N_3{}^+ + N_2$	$1.7 \times 10^{-29} \exp(300/T_g)^{2.1}$	[71]
im5	$N_2{}^+ + N_2 + N_2 \longrightarrow N_4{}^+ + N_2$	$6.8 \times 10^{-29} (300/T_g)^{1.64}$	[52]
im6	$N_{2}{}^{\scriptscriptstyle +} + H_2 \longrightarrow N_2 H^+ + H$	1.7×10 ⁻⁹	[52]
im7	$N_2{}^+ + NH_3 \longrightarrow NH_3{}^+ + N_2$	1.95×10 ⁻⁹	[49]
im8	$N_2{}^+ + N(S) + N_2 {\longrightarrow} N_3{}^+ + N_2$	$0.9 \times 10^{-29} \exp(400/T_g)$	[71]
im9	$N_2{}^+ + N_2(A) \longrightarrow N_3{}^+ + N$	3×10 ⁻¹⁰	[71]
im10	$N_{3^{+}} + N(S) \longrightarrow N_{2^{+}} + N_{2}$	6.6×10 ⁻¹¹	[71]
im11	$N_4{}^+ + N_2 \longrightarrow N_2{}^+ + N_2(X,0) + N_2$	$2.1 \times 10^{-16} \exp(T_g/120)$	[52]
im12	$N_{4^{+}} + H_{2} \longrightarrow H + N_{2} + N_{2} H^{+} \label{eq:N4}$	1.139×10 ⁻⁸	[52]
im13	$N_{4^+} + H_2 \longrightarrow 2N_2 + H_{2^+}$	$3.0 \times 10^{-10} \exp(-1800/T_g)$	[52]
im14	$\mathrm{H^{+}} + \mathrm{H_{2}} \longrightarrow \mathrm{H} + \mathrm{H_{2^{+}}}$	2.5×10 ⁻⁹	[96]
im15	$H^+ + 2H_2 \longrightarrow 2H + H_3^+$	$3.1 \times 10^{-29} (300/T_g)^{0.5}$	[96]
im16	$H^+ + M \longrightarrow H + M^+ M{=}NH_x x{=}1{-}3$	5.0×10 ⁻¹¹	[65]
im17	$H_2{}^+ + H_2 \longrightarrow H_3{}^+ + H$	2.1×10 ⁻⁹	[52]

im18

im19

 $H_{2^{+}}+N_{2} \rightarrow N_{2}H^{+}+H$

 $H_{2^{+}} + H \rightarrow H_{2} + H^{+}$

1.95×10-9

 6.4×10^{-10}

[52]

[65]

$H_{2^+} + NH_x \longrightarrow H + NH_{x+1^+} x{=}1{-}3$	5.0×10^{-11}	[65]
$H_{2^+} + M \longrightarrow H_2 + M^+$	5.0×10 ⁻¹⁰	[65]
$H_{3}{}^{\scriptscriptstyle +} + N_2 \longrightarrow N_2 H^+ + H_2$	1.8×10^{-9}	[52]
$\mathrm{H_{3^+} + NH_3 \rightarrow H_2 + NH_{4^+}}$	4.4×10 ⁻⁹	[65]
$N_2H^+ + NH_3 \rightarrow NH_{4^+} + N_2$	2.3×10 ⁻⁹	[49]
$NH^+ + H_2 \rightarrow H + NH_{2^+}$	1.0×10^{-9}	[65]
$\rm NH^{\scriptscriptstyle +} + \rm NH_2 \rightarrow \rm NH + \rm NH_{2^{\scriptscriptstyle +}}$	1.8×10^{-9}	[65]
$\rm NH^{+} + \rm NH_{3} \rightarrow \rm NH + \rm NH_{3^{+}}$	1.8×10^{-9}	[65]
$NH^{\scriptscriptstyle +} + NH_3 \longrightarrow N + NH_{4^{\scriptscriptstyle +}}$	6.0×10^{-10}	[65]
$NH_{2^{+}} + NH_{3} \rightarrow NH_{2} + NH_{3^{+}}$	1.1×10^{-9}	[65]
$NH_{2^{+}} + NH_{3} \rightarrow NH + NH_{4^{+}}$	1.1×10^{-9}	[65]
$NH_{3^+} + NH_3 \rightarrow H + NH_2 + NH_{3^+}$	2.0×10^{-10}	[65]
$NH_{3^+} + NH_3 \rightarrow NH_2 + NH_{4^+}$	2.2×10 ⁻⁹	[65]
$NH_{3^{+}} + H_{2} \longrightarrow H + NH_{4^{+}}$	4.0×10 ⁻¹³	[65]
$\mathrm{H}^- + \mathrm{H} \rightarrow \mathrm{H}_2 + \mathrm{e}$	1.8×10^{-9}	[52]
$H^- + NH_3 \rightarrow H_2 + NH_2^-$	8.8×10 ⁻¹³	[65]
$NH_2^- + H_2 \longrightarrow NH_3 + H^-$	2.3×10 ⁻¹¹	[65]
	$\begin{split} H_{2}^{+} + NH_{x} &\rightarrow H + NH_{x+1}^{+} x=1-3 \\ H_{2}^{+} + M \rightarrow H_{2} + M^{+} \\ H_{3}^{+} + N_{2} \rightarrow N_{2}H^{+} + H_{2} \\ H_{3}^{+} + NH_{3} \rightarrow H_{2} + NH_{4}^{+} \\ N_{2}H^{+} + NH_{3} \rightarrow NH_{4}^{+} + N_{2} \\ NH^{+} + H_{2} \rightarrow H + NH_{2}^{+} \\ NH^{+} + NH_{2} \rightarrow NH + NH_{2}^{+} \\ NH^{+} + NH_{3} \rightarrow NH + NH_{3}^{+} \\ NH^{+} + NH_{3} \rightarrow N + NH_{4}^{+} \\ NH_{2}^{+} + NH_{3} \rightarrow NH_{2} + NH_{3}^{+} \\ NH_{2}^{+} + NH_{3} \rightarrow NH_{2} + NH_{3}^{+} \\ NH_{3}^{+} + NH_{3} \rightarrow H + NH_{2} + NH_{3}^{+} \\ NH_{3}^{+} + NH_{3} \rightarrow NH_{2} + NH_{4}^{+} \\ NH_{3}^{+} + H_{3} \rightarrow NH_{2} + NH_{4}^{+} \\ NH_{3}^{+} + H_{3} \rightarrow H_{2} + NH_{4}^{+} \\ H^{-} + H \rightarrow H_{2} + e \\ H^{-} + NH_{3} \rightarrow H_{2} + NH_{2}^{-} \\ NH_{2}^{-} + H_{2} \rightarrow NH_{3} + H^{-} \end{split}$	$\begin{split} H_2^+ + NH_x &\rightarrow H + NH_{x+1}^+ x=1-3 & 5.0\times 10^{-11} \\ H_2^+ + M &\rightarrow H_2 + M^+ & 5.0\times 10^{-10} \\ H_3^+ + NH_3 &\rightarrow N_2 + NH_4^+ & 4.4\times 10^{-9} \\ N_2H^+ + NH_3 &\rightarrow NH_4^+ + N_2 & 2.3\times 10^{-9} \\ NH^+ + H_2 &\rightarrow H + NH_2^+ & 1.0\times 10^{-9} \\ NH^+ + NH_3 &\rightarrow NH + NH_2^+ & 1.8\times 10^{-9} \\ NH^+ + NH_3 &\rightarrow NH + NH_3^+ & 1.8\times 10^{-9} \\ NH^+ + NH_3 &\rightarrow NH + NH_4^+ & 6.0\times 10^{-10} \\ NH_2^+ + NH_3 &\rightarrow NH_2 + NH_3^+ & 1.1\times 10^{-9} \\ NH_2^+ + NH_3 &\rightarrow NH_2 + NH_3^+ & 1.1\times 10^{-9} \\ NH_3^+ + NH_3 &\rightarrow NH_2 + NH_4^+ & 2.0\times 10^{-10} \\ NH_3^+ + NH_3 &\rightarrow NH_2 + NH_4^+ & 4.0\times 10^{-13} \\ H^- + H &\rightarrow H_2 + RH_4^- & 1.8\times 10^{-9} \\ NH_3^- + H_3 &\rightarrow H_2 + NH_4^+ & 4.0\times 10^{-13} \\ H^- + H &\rightarrow H_2 + NH_2^- & 8.8\times 10^{-13} \\ NH_2^- + H_2 &\rightarrow NH_3 + H^- & 2.3\times 10^{-11} \\ \end{split}$

Ion-ion recombination		Rate coefficien t	
ii1	$\rm H^- + H^+ \rightarrow 2H$	$8.73 \times 10^{-9} (300/T_g)^{0.5}$	[97]
ii2	$\mathrm{H}^- + \mathrm{H}_2^+ \longrightarrow \mathrm{H}_2 + \mathrm{H}$	$2.91 \times 10^{-9} (300/T_g)^{0.5}$	[97]
ii3	$\mathrm{H^-} + \mathrm{H_{3^+}} \rightarrow 2\mathrm{H_2}$	$2.0 \times 10^{-7} (300/T_g)^{0.5}$	[96]
ii4	$H^- + M^+ \longrightarrow H + M M = NH_x^+, N^+ x = 1 - 3$	3.0×10 ⁻⁶	[65]
ii5	$H^- + NH_4^+ \longrightarrow NH_3 + H_2$	3.0×10 ⁻⁶	[65]
ii6	$NH_{2}^{-} + NH_{4}^{+} \rightarrow NH_{3} + NH_{2} + H$	2.0×10 ⁻⁷	[65]
ii7	$NH_{2^{-}} + M^{+} \rightarrow NH_{2} + M M{=}NH_{x^{+}}, N^{+} x{=}1{-}3$	2.0×10 ⁻⁷	[65]
ii8	$NH_{2}^{-} + H_{3}^{+} \longrightarrow NH_{3} + H_{2}$	1.0×10^{-7}	[65]
ii9	$NH_2^- + H_3^+ \longrightarrow NH_2 + H_2 + H$	1.0×10^{-7}	[65]

Spontan	eous emission	Frequency	
em1	$N_2(B) \rightarrow N_2(A) + h\nu$	2.0×10 ⁵	[60]
em2	$N_2(C) \rightarrow N_2(B) + h\nu$	2.74×10^{7}	[60]
em3	$N_2(a) \rightarrow N_2(X,0) + h\nu$	1.8×10^{4}	[60,98]
em4	$N_2(a) \rightarrow N_2(a') + h\nu$	1.91×10^{2}	[60]
em5	$N_2(w) \rightarrow N_2(a) + hv$	6.5×10^{2}	[60]

Sticking		Coefficient	
w1	$H + F \rightarrow H(s)$	1.0	[47]

w2	$N + F \rightarrow N(s)$	1.0	[47]
w3	$NH + F \rightarrow NH(s)$	1.0	[47]
w4	$NH_2 + F \rightarrow NH_2(s)$	1.0	[47]
Dissoc	iative adsorption	Coefficient	
w5	$N_2 + 2F \rightarrow 2N(s)$	1.0×10 ⁻³	[58]
w6	$H_2 + 2F \rightarrow 2H(s)$	3.5×10 ⁻⁷	[58]
Eley-R	ideal	Coefficient	
w7	$\mathrm{H} + \mathrm{H}(s) \longrightarrow \mathrm{H}_2 + \mathrm{F}$	3.5×10 ⁻³	[47]
w8	$N+N(s) \longrightarrow N_2+F$	1.2×10 ⁻²	[47]
w9	$N + H(s) \rightarrow NH(s)$	1.5×10 ⁻³	а
w10	$\mathrm{H} + \mathrm{N}(\mathrm{s}) \to \mathrm{NH}(\mathrm{s})$	1.2×10 ⁻³	а
w11	$\mathrm{H} + \mathrm{NH}(\mathrm{s}) \to \mathrm{NH}_2(\mathrm{s})$	1.2×10^{-3}	а
w12	$\mathrm{NH} + \mathrm{H}(\mathrm{s}) \rightarrow \mathrm{NH}_2(\mathrm{s})$	1.5×10 ⁻³	а
w13	$H + NH_2(s) \rightarrow NH_3 + F$	1.2×10 ⁻³	а
w14	$H(s) + NH_2 \rightarrow NH_3 + F$	1.5×10 ⁻³	а
w15	$H_2 + NH(s) \rightarrow NH_3 + F$	1.2×10^{-4}	а
Langm	uir-Hinshelwood	Elh	
w16	$\mathrm{NH}(s) + \mathrm{H}(s) \to \mathrm{NH}_2(s) + \mathrm{F}$	0.70	а
w17	$H(s) + NH_2(s) \rightarrow NH_3 + 2F$	0.60	а
w18	$N(s) + H(s) \rightarrow NH(s)$	1.5	а
Surface	e deexcitation and neutralization	Coefficient	
w19	$N_2(A) + wall \rightarrow N_2(X,0)$	1.0	[60]
w20	$N_2(a') + wall \rightarrow N_2(X,0)$	1.0	[60]
w20 w21	$N_2(a') + wall \rightarrow N_2(X,0)$ $N_2(a) + wall \rightarrow N_2(X,0)$	1.0 1.0	[60] [60]
w20 w21 w22	$\begin{split} N_2(a') + & \text{wall} \to N_2(X,0) \\ N_2(a) + & \text{wall} \to N_2(X,0) \\ N_2(w) + & \text{wall} \to N_2(X,0) \end{split}$	1.0 1.0 1.0	[60] [60] [60]
w20 w21 w22 w23	$\begin{split} N_2(a') + & \text{wall} \to N_2(X,0) \\ N_2(a) + & \text{wall} \to N_2(X,0) \\ N_2(w) + & \text{wall} \to N_2(X,0) \\ N(D) + & \text{wall} \to N(S) \end{split}$	1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 	$\begin{split} N_2(a') + & \text{wall} \to N_2(X,0) \\ N_2(a) + & \text{wall} \to N_2(X,0) \\ N_2(w) + & \text{wall} \to N_2(X,0) \\ N(D) + & \text{wall} \to N(S) \\ N(P) + & \text{wall} \to N(S) \end{split}$	1.0 1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 	$\begin{split} N_2(a') + & \text{wall} \to N_2(X,0) \\ N_2(a) + & \text{wall} \to N_2(X,0) \\ N_2(w) + & \text{wall} \to N_2(X,0) \\ N(D) + & \text{wall} \to N(S) \\ N(P) + & \text{wall} \to N(S) \\ N^+ + & \text{wall} \to N \end{split}$	1.0 1.0 1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 	$\begin{split} N_2(a') + & \text{wall} \to N_2(X,0) \\ N_2(a) + & \text{wall} \to N_2(X,0) \\ N_2(w) + & \text{wall} \to N_2(X,0) \\ N(D) + & \text{wall} \to N(S) \\ N(P) + & \text{wall} \to N(S) \\ N^+ + & \text{wall} \to N \\ N_2^+ + & \text{wall} \to N_2 \end{split}$	1.0 1.0 1.0 1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 	$\begin{split} N_2(a') + & wall \rightarrow N_2(X,0) \\ N_2(a) + & wall \rightarrow N_2(X,0) \\ N_2(w) + & wall \rightarrow N_2(X,0) \\ N(D) + & wall \rightarrow N(S) \\ N(P) + & wall \rightarrow N(S) \\ N^+ + & wall \rightarrow N \\ N_2^+ + & wall \rightarrow N_2 \\ N_3^+ + & wall \rightarrow N_2 + N \end{split}$	1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 	$\begin{split} N_2(a') + & wall \rightarrow N_2(X,0) \\ N_2(a) + & wall \rightarrow N_2(X,0) \\ N_2(w) + & wall \rightarrow N_2(X,0) \\ N(D) + & wall \rightarrow N(S) \\ N(P) + & wall \rightarrow N(S) \\ N^+ + & wall \rightarrow N \\ N_2^+ + & wall \rightarrow N_2 \\ N_3^+ + & wall \rightarrow N_2 + N \\ N_4^+ + & wall \rightarrow 2N_2 \end{split}$	1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 	$\begin{split} N_2(a') + & \text{wall} \rightarrow N_2(X,0) \\ N_2(a) + & \text{wall} \rightarrow N_2(X,0) \\ N_2(w) + & \text{wall} \rightarrow N_2(X,0) \\ N(D) + & \text{wall} \rightarrow N(S) \\ N(P) + & \text{wall} \rightarrow N(S) \\ N^+ + & \text{wall} \rightarrow N \\ N_2^+ + & \text{wall} \rightarrow N_2 \\ N_3^+ + & \text{wall} \rightarrow N_2 + N \\ N_4^+ + & \text{wall} \rightarrow 2N_2 \\ H^+ + & \text{wall} \rightarrow H \end{split}$	$ \begin{array}{c} 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ 1.0 \\ \end{array} $	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 	$\begin{split} N_2(a') + wall &\rightarrow N_2(X,0) \\ N_2(a) + wall &\rightarrow N_2(X,0) \\ N_2(w) + wall &\rightarrow N_2(X,0) \\ N(D) + wall &\rightarrow N(S) \\ N(P) + wall &\rightarrow N(S) \\ N^+ + wall &\rightarrow N(S) \\ N_2^+ + wall &\rightarrow N_2 \\ N_3^+ + wall &\rightarrow N_2 + N \\ N_4^+ + wall &\rightarrow N_2 + N \\ N_4^+ + wall &\rightarrow H \\ H_2^+ + wall &\rightarrow H_2 \end{split}$	$ \begin{array}{c} 1.0 \\ 1.$	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 	$\begin{split} N_2(a') + & wall \rightarrow N_2(X,0) \\ N_2(a) + & wall \rightarrow N_2(X,0) \\ N_2(w) + & wall \rightarrow N_2(X,0) \\ N(D) + & wall \rightarrow N(S) \\ N(P) + & wall \rightarrow N(S) \\ N^+ + & wall \rightarrow N(S) \\ N_2^+ + & wall \rightarrow N_2 \\ N_3^+ + & wall \rightarrow N_2 + N \\ N_4^+ + & wall \rightarrow N_2 + N \\ N_4^+ + & wall \rightarrow H \\ H_2^+ + & wall \rightarrow H_2 \\ H_3^+ + & wall \rightarrow H_2 + H \end{split}$	$ \begin{array}{c} 1.0 \\ 1.$	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 w32 	$\begin{split} N_2(a') + & \text{wall} \rightarrow N_2(X,0) \\ N_2(a) + & \text{wall} \rightarrow N_2(X,0) \\ N_2(w) + & \text{wall} \rightarrow N_2(X,0) \\ N(D) + & \text{wall} \rightarrow N(S) \\ N(P) + & \text{wall} \rightarrow N(S) \\ N^+ + & \text{wall} \rightarrow N(S) \\ N_2^+ + & \text{wall} \rightarrow N_2 \\ N_3^+ + & \text{wall} \rightarrow N_2 + N \\ N_4^+ + & \text{wall} \rightarrow N_2 + N \\ N_4^+ + & \text{wall} \rightarrow H \\ H_2^+ + & \text{wall} \rightarrow H_2 \\ H_3^+ + & \text{wall} \rightarrow H_2 + H \\ N_2H^+ + & \text{wall} \rightarrow H + N_2 \end{split}$	$ \begin{array}{r} 1.0 \\ $	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 w32 w33 	$\begin{split} N_2(a') + wall &\rightarrow N_2(X,0) \\ N_2(a) + wall &\rightarrow N_2(X,0) \\ N_2(w) + wall &\rightarrow N_2(X,0) \\ N(D) + wall &\rightarrow N(S) \\ N(P) + wall &\rightarrow N(S) \\ N^+ + wall &\rightarrow N(S) \\ N_2^+ + wall &\rightarrow N_2 \\ N_3^+ + wall &\rightarrow N_2 + N \\ N_4^+ + wall &\rightarrow N_2 + N \\ N_4^+ + wall &\rightarrow H \\ H_2^+ + wall &\rightarrow H_2 \\ H_3^+ + wall &\rightarrow H_2 + H \\ N_2H^+ + wall &\rightarrow H_2 + H \\ N_2H^+ + wall &\rightarrow H + N_2 \\ NH^+ + wall &\rightarrow NH \end{split}$	$ \begin{array}{r} 1.0 \\ $	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 w32 w33 w34 	$\begin{split} &N_2(a') + \text{wall} \rightarrow N_2(X,0) \\ &N_2(a) + \text{wall} \rightarrow N_2(X,0) \\ &N_2(w) + \text{wall} \rightarrow N_2(X,0) \\ &N(D) + \text{wall} \rightarrow N(S) \\ &N(P) + \text{wall} \rightarrow N(S) \\ &N'' + \text{wall} \rightarrow N(S) \\ &N_2^+ + \text{wall} \rightarrow N_2 \\ &N_3^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow 2N_2 \\ &H^+ + \text{wall} \rightarrow H \\ &H_2^+ + \text{wall} \rightarrow H_2 \\ &H_3^+ + \text{wall} \rightarrow H_2 + H \\ &N_2H^+ + \text{wall} \rightarrow H + N_2 \\ &NH^+ + \text{wall} \rightarrow NH \\ &NH_2^+ + \text{wall} \rightarrow NH_2 \end{split}$	$ \begin{array}{r} 1.0 \\ $	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 w32 w33 w34 w35 	$\begin{split} &N_2(a') + \text{wall} \rightarrow N_2(X,0) \\ &N_2(a) + \text{wall} \rightarrow N_2(X,0) \\ &N_2(w) + \text{wall} \rightarrow N_2(X,0) \\ &N(D) + \text{wall} \rightarrow N(S) \\ &N(P) + \text{wall} \rightarrow N(S) \\ &N' + \text{wall} \rightarrow N(S) \\ &N' + \text{wall} \rightarrow N_2 \\ &N_2^+ + \text{wall} \rightarrow N_2 \\ &N_3^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow 2N_2 \\ &H^+ + \text{wall} \rightarrow H \\ &H_2^+ + \text{wall} \rightarrow H_2 \\ &H_3^+ + \text{wall} \rightarrow H_2 + H \\ &N_2H^+ + \text{wall} \rightarrow H_2 + H \\ &N_2H^+ + \text{wall} \rightarrow H + N_2 \\ &NH^+ + \text{wall} \rightarrow NH \\ &NH_2^+ + \text{wall} \rightarrow NH_3 \end{split}$	1.0 1.0	[60] [60] [60] [60]
 w20 w21 w22 w23 w24 w25 w26 w27 w28 w29 w30 w31 w32 w33 w34 w35 w36 	$\begin{split} &N_2(a') + \text{wall} \rightarrow N_2(X,0) \\ &N_2(a) + \text{wall} \rightarrow N_2(X,0) \\ &N_2(w) + \text{wall} \rightarrow N_2(X,0) \\ &N(D) + \text{wall} \rightarrow N(S) \\ &N(P) + \text{wall} \rightarrow N(S) \\ &N' + \text{wall} \rightarrow N(S) \\ &N' + \text{wall} \rightarrow N_2 \\ &N_3^+ + \text{wall} \rightarrow N_2 \\ &N_3^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow N_2 + N \\ &N_4^+ + \text{wall} \rightarrow H \\ &H_2^+ + \text{wall} \rightarrow H_2 \\ &H_3^+ + \text{wall} \rightarrow H_2 + H \\ &N_2H^+ + \text{wall} \rightarrow H_2 + H \\ &N_2H^+ + \text{wall} \rightarrow H + N_2 \\ &NH_4^+ + \text{wall} \rightarrow NH_3 \\ &NH_4^+ + \text{wall} \rightarrow NH_3 + H \end{split}$	1.0 1.0	[60] [60] [60] [60]

a: assumed in this work (see text) F stands for a free surface site